

High-Precision Processing of Glass for Various Applications

Ernestas Nacius

WOP | Workshop of Photonics, Lithuania



Laser processing
solution provider

Exceptional expertise
in **glass processing**

3 M holes in 45 minutes



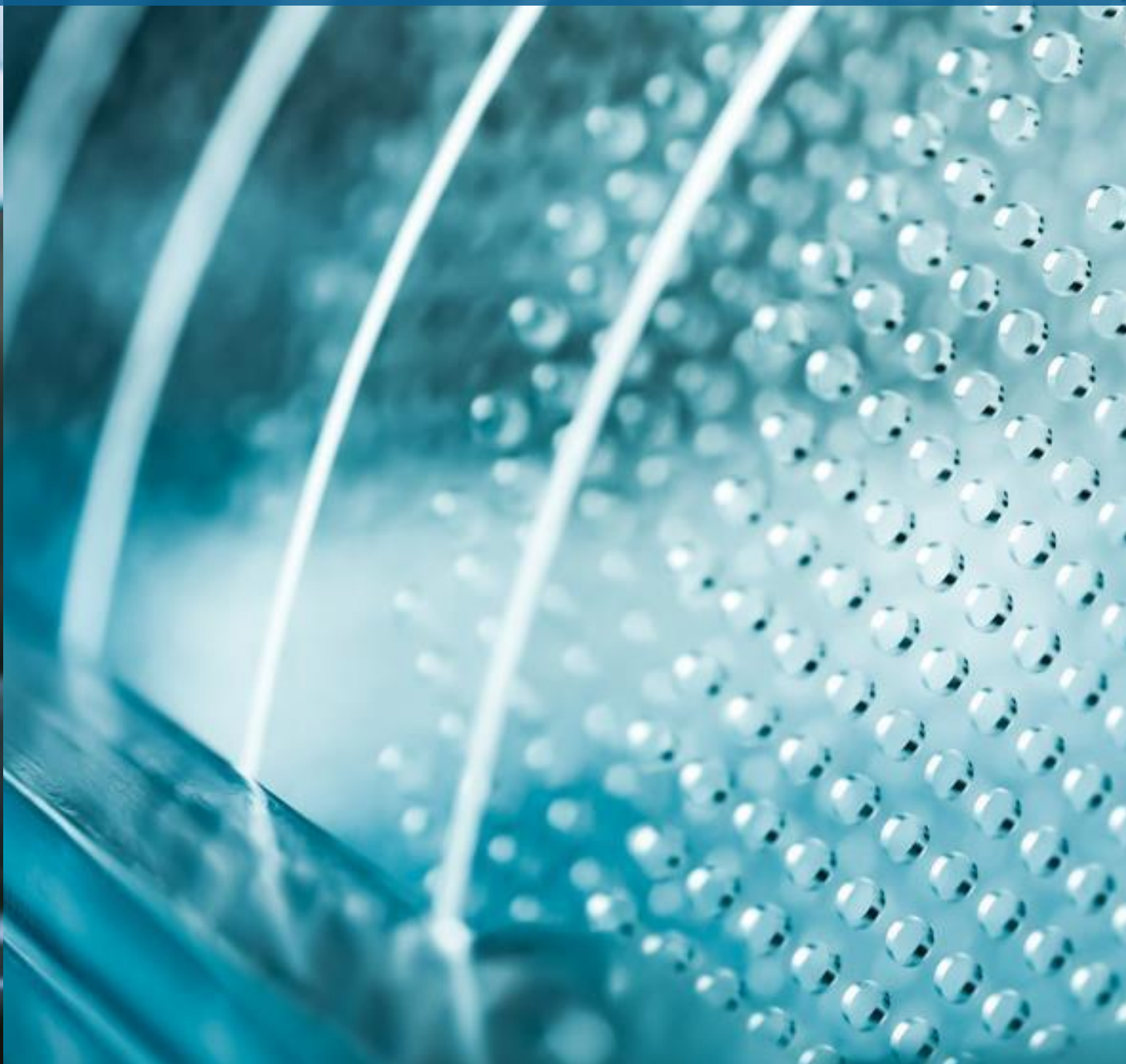
Solution
development | R&D



Contract
manufacturing



Hardware |
laser systems



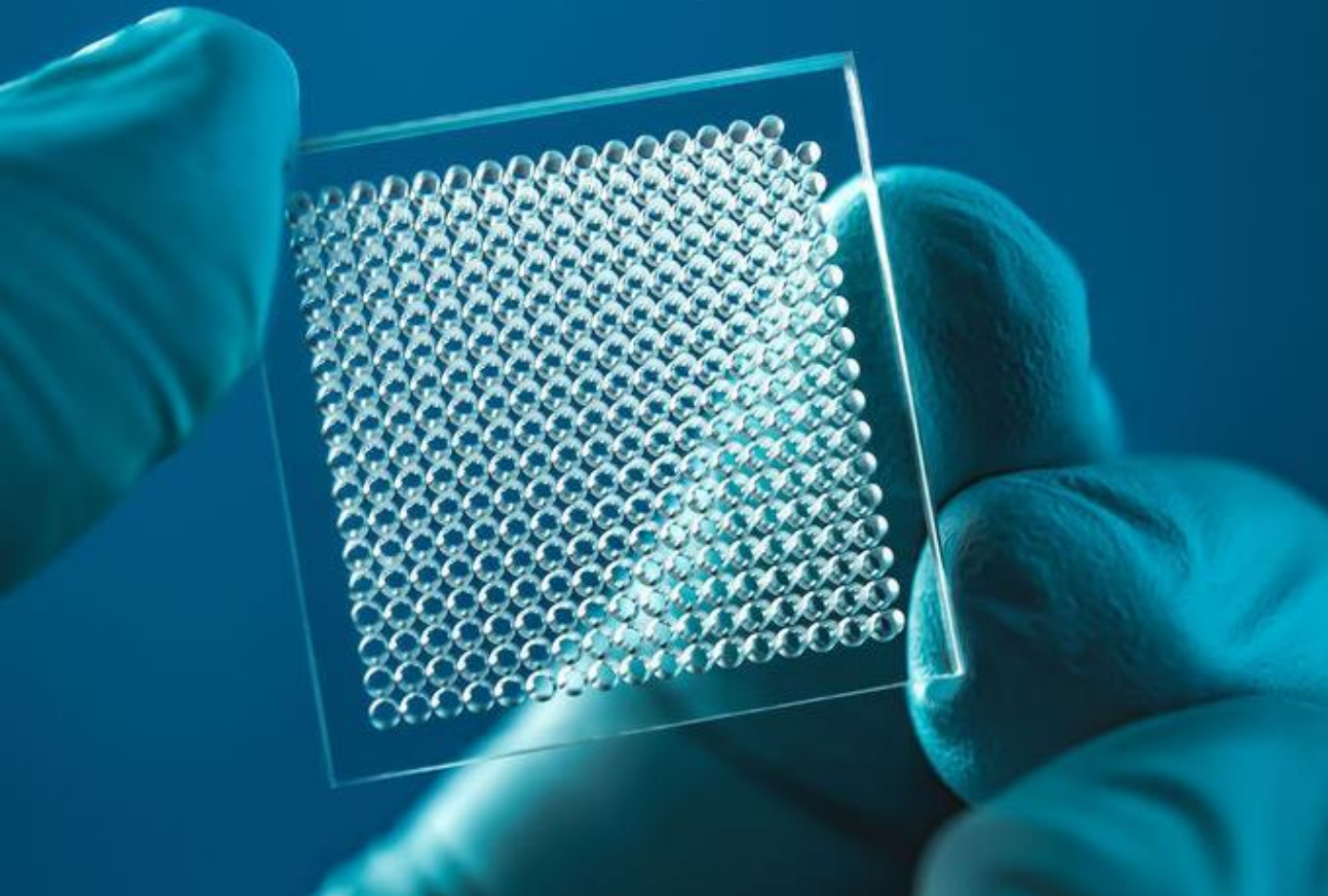
FEMTO
GLASS

WCP

WOP glass technologies



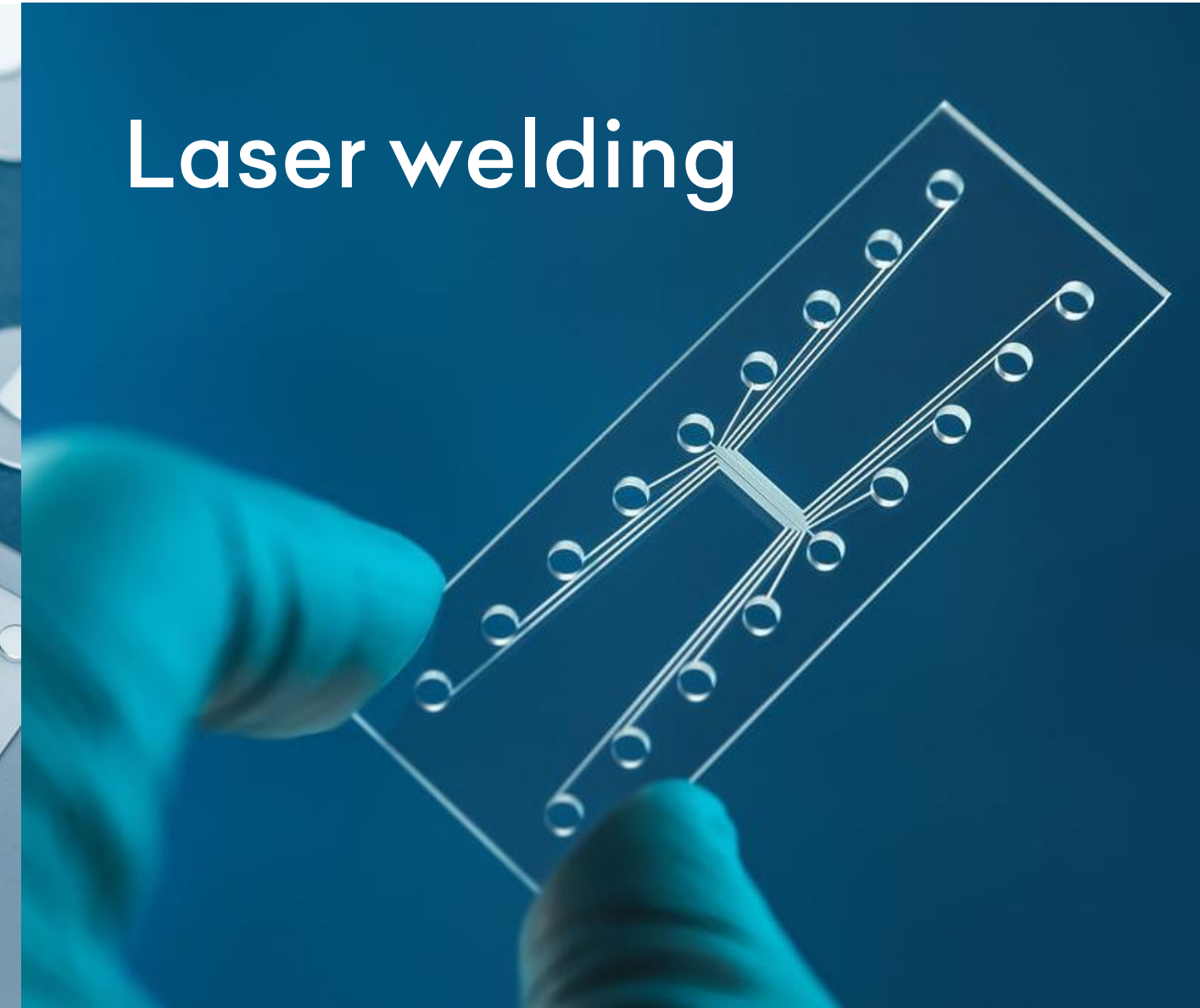
Micro drilling with SLE



Micro cutting



Laser welding



All glass types | All glass producers

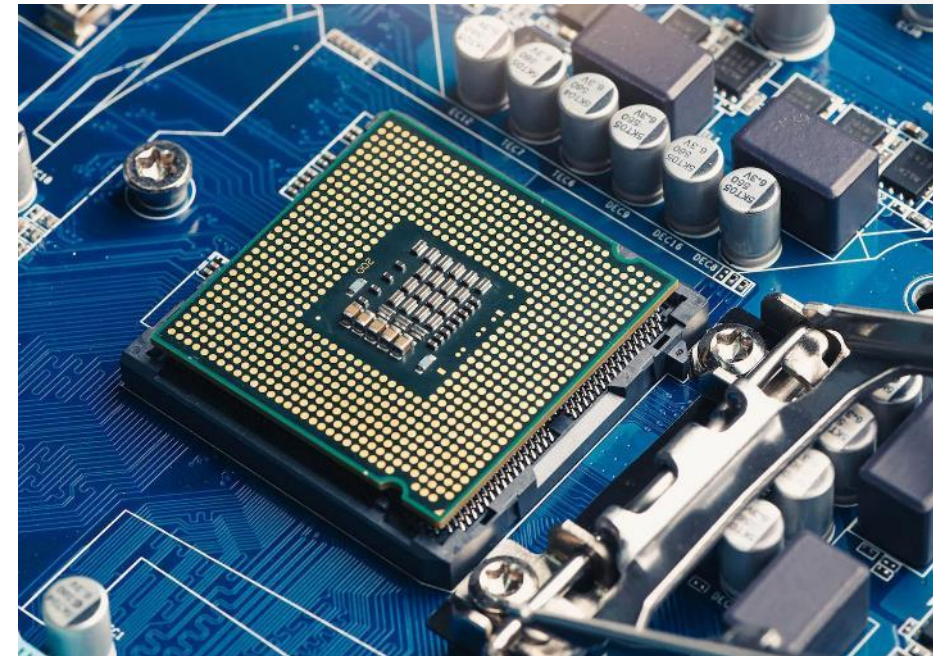
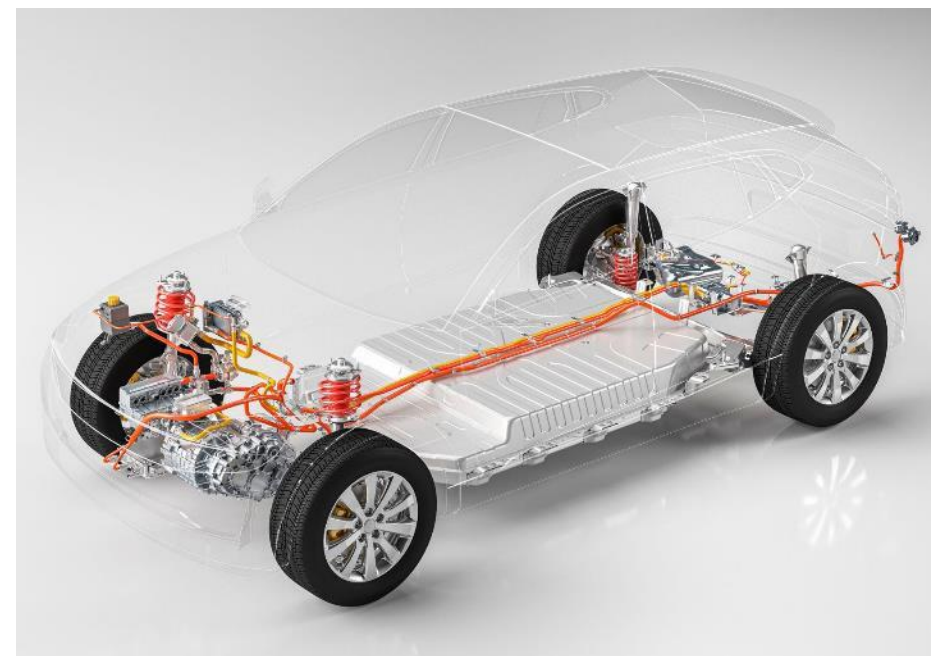
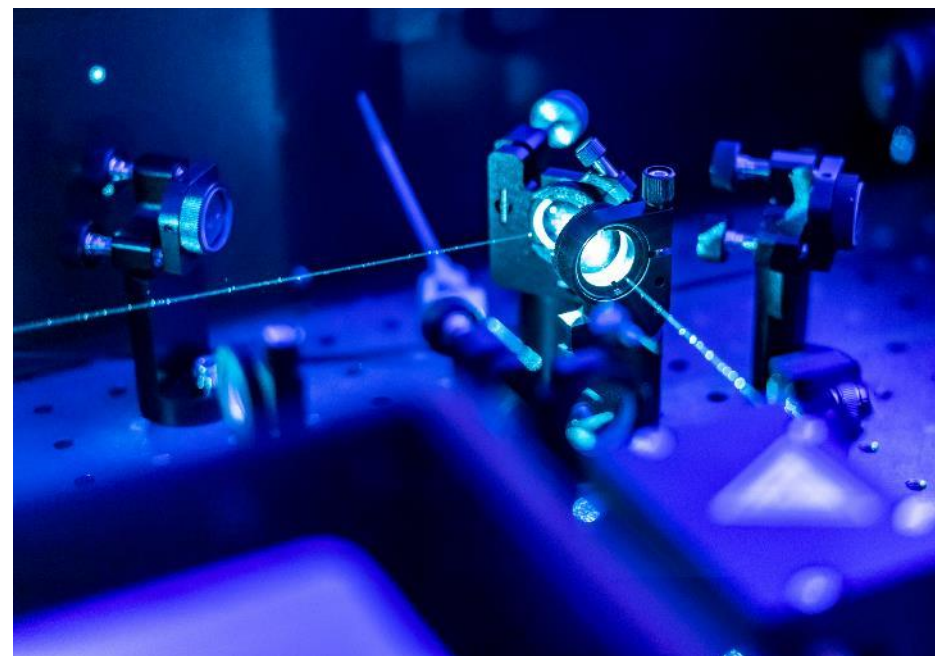
When choose our glass technologies?

In need for **smallest feature size** possible

In need for **precision & quality**



- Biotechnology & Medical
- Semiconductors
- Laser manufacturers
- Automotive
- Aerospace & Defense
- Universities and R&D
- Any others who need micro solution



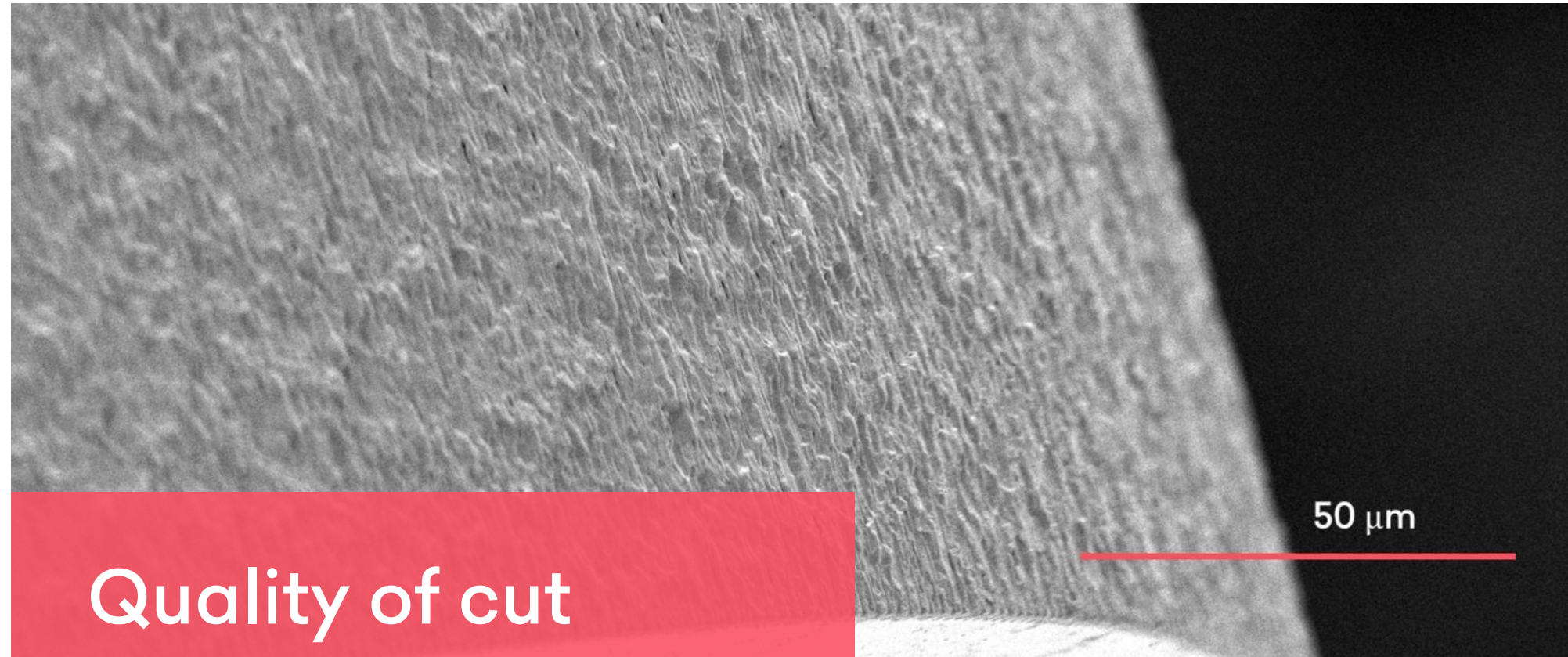
Perfect glass ⁺ cuts

D236T glass, thickness 300 μm

200 μm

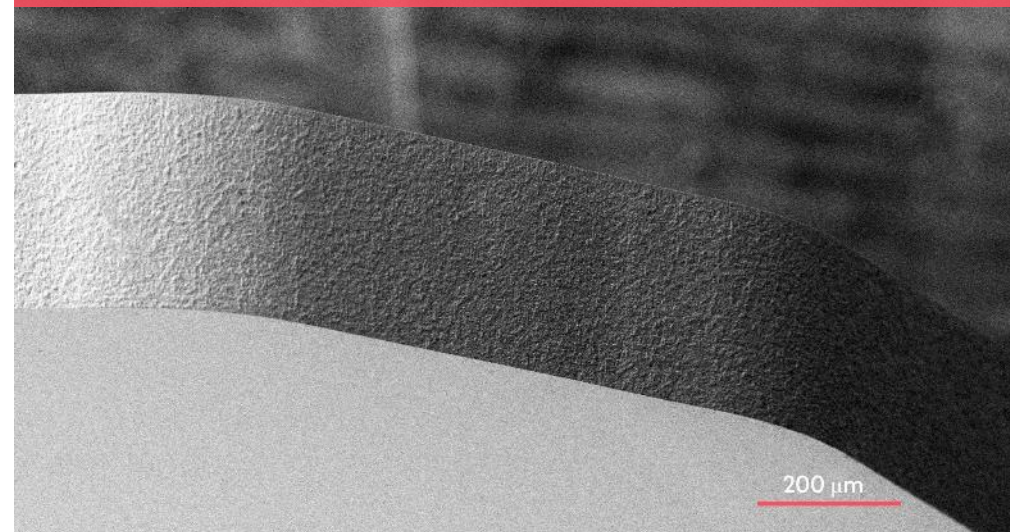


Glass & sapphire cutting

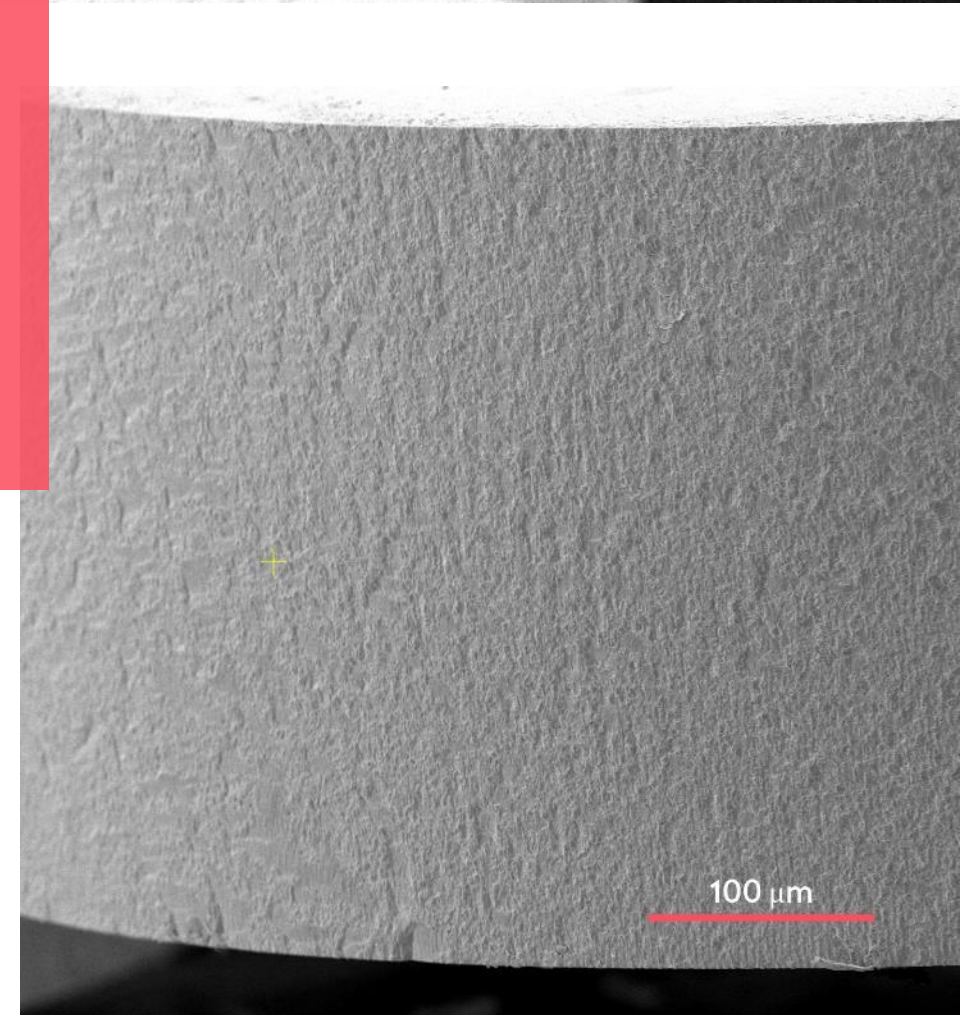


Quality of cut

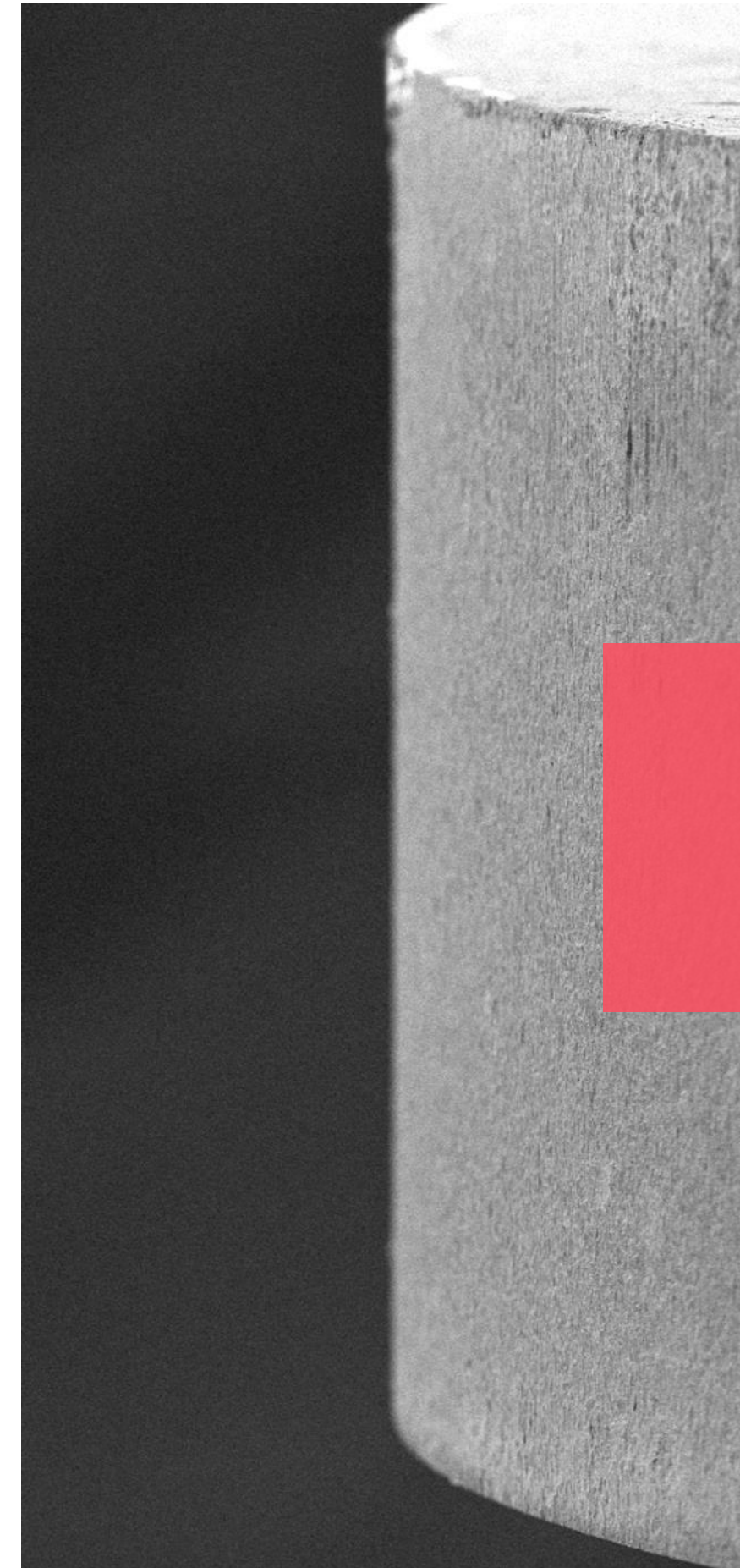
- Cut width less than 1 μm
- Low chipping <20 μm
- No post-processing required



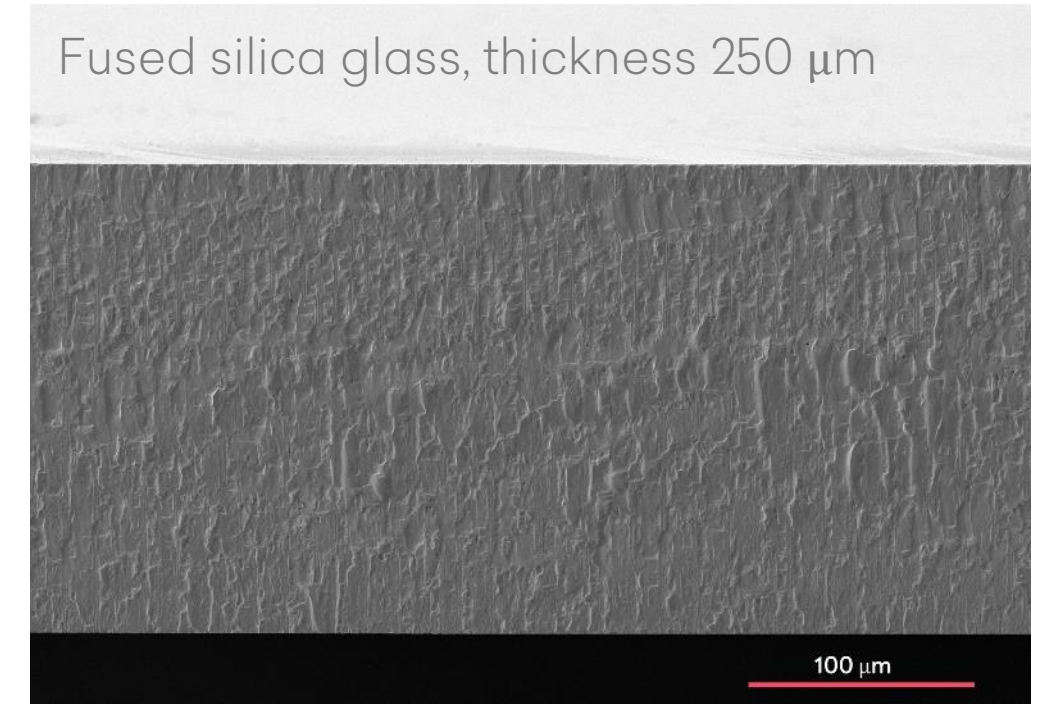
D236T glass, thickness 300 μm



Sapphire, thickness 400 μm



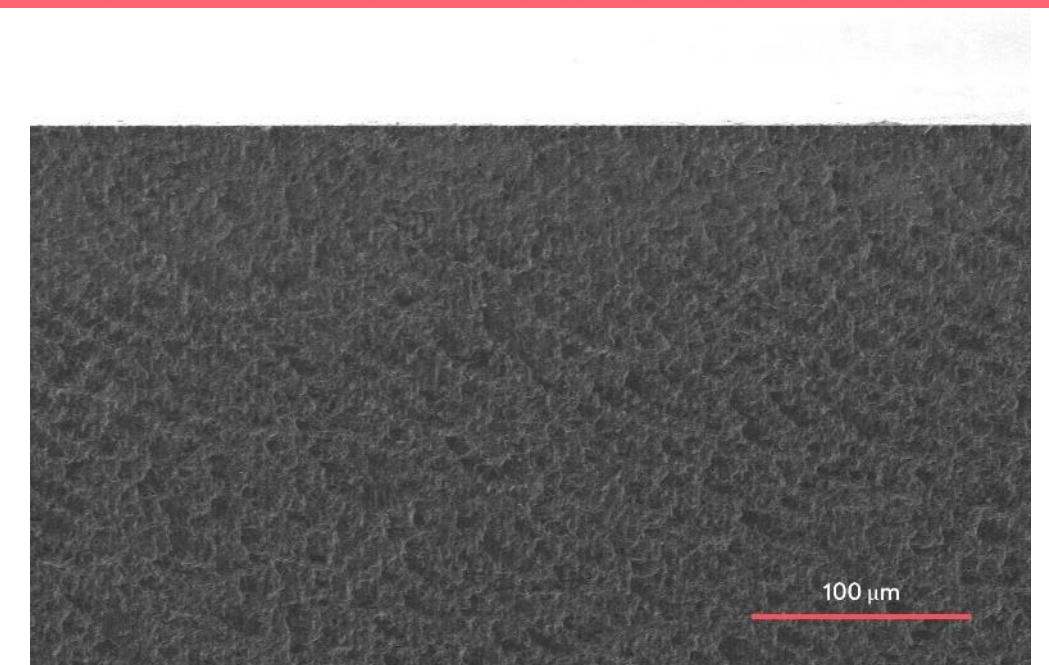
Sapphire, thickness 700 μm



Fused silica glass, thickness 250 μm

Type of glass

- Tempered
- Non tempered
- Sapphire



Sapphire, thickness 700 μm

Glass cutting

Features




Patented glass & sapphire dicing technology



From ultra-thin glass to 10 mm



High process speed up to 800 mm/s



All shapes: circular, square, irregular



Inner and outer contours



Tunable dicing process for different substrate thickness

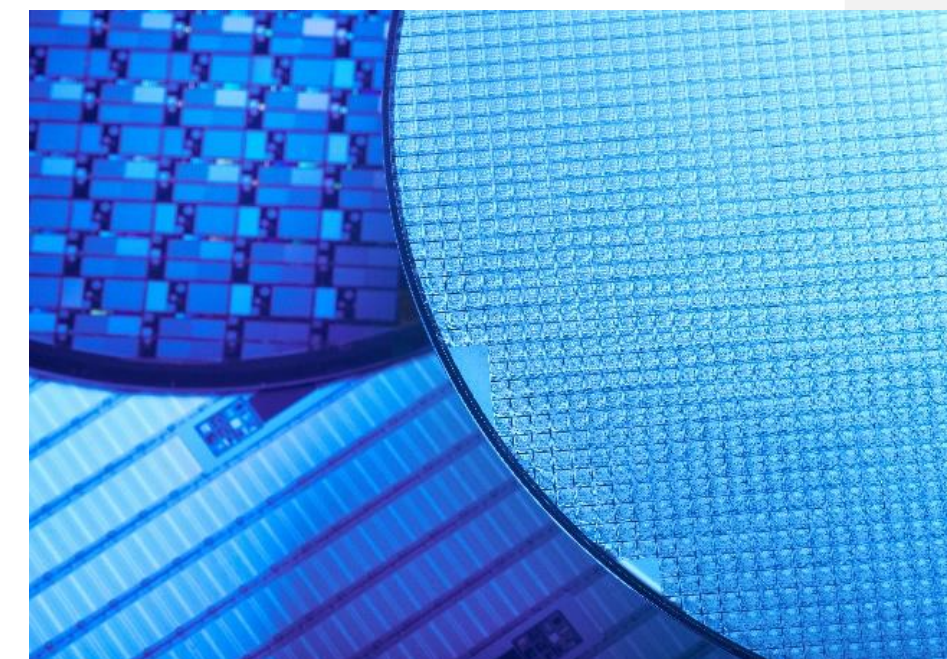
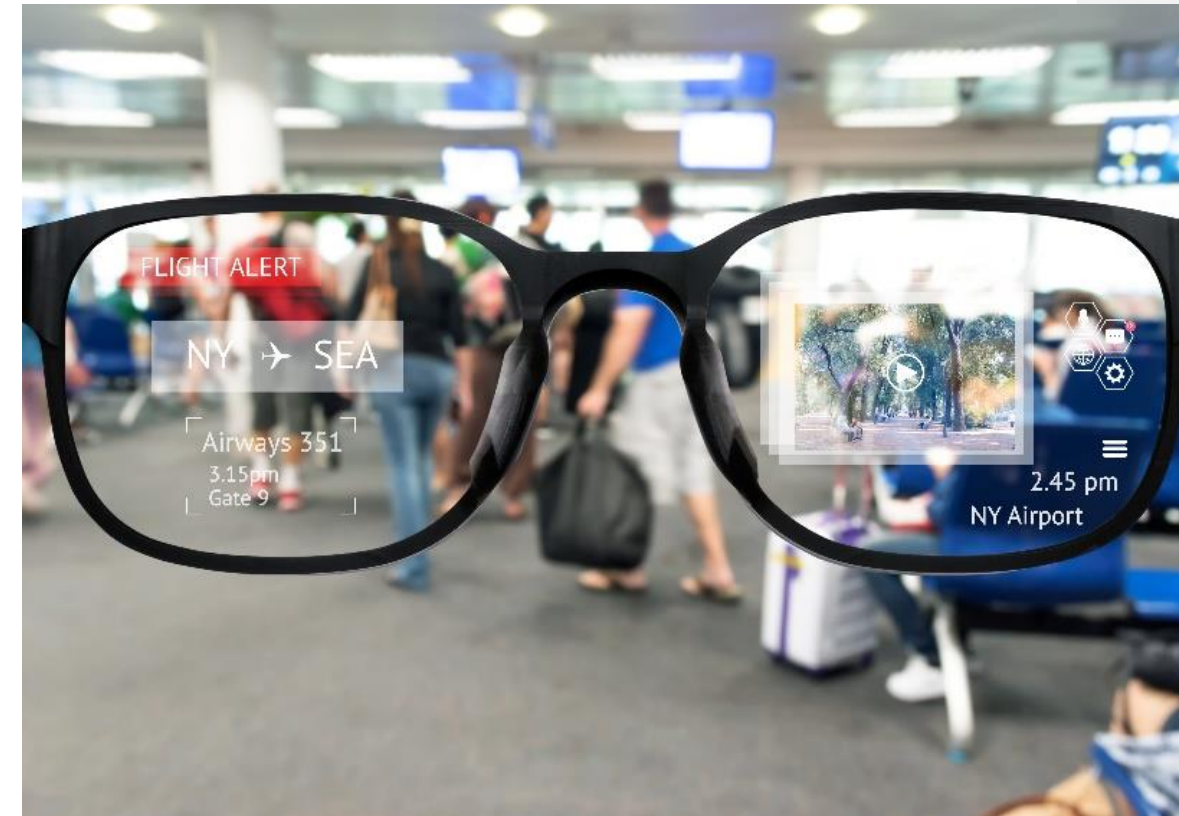
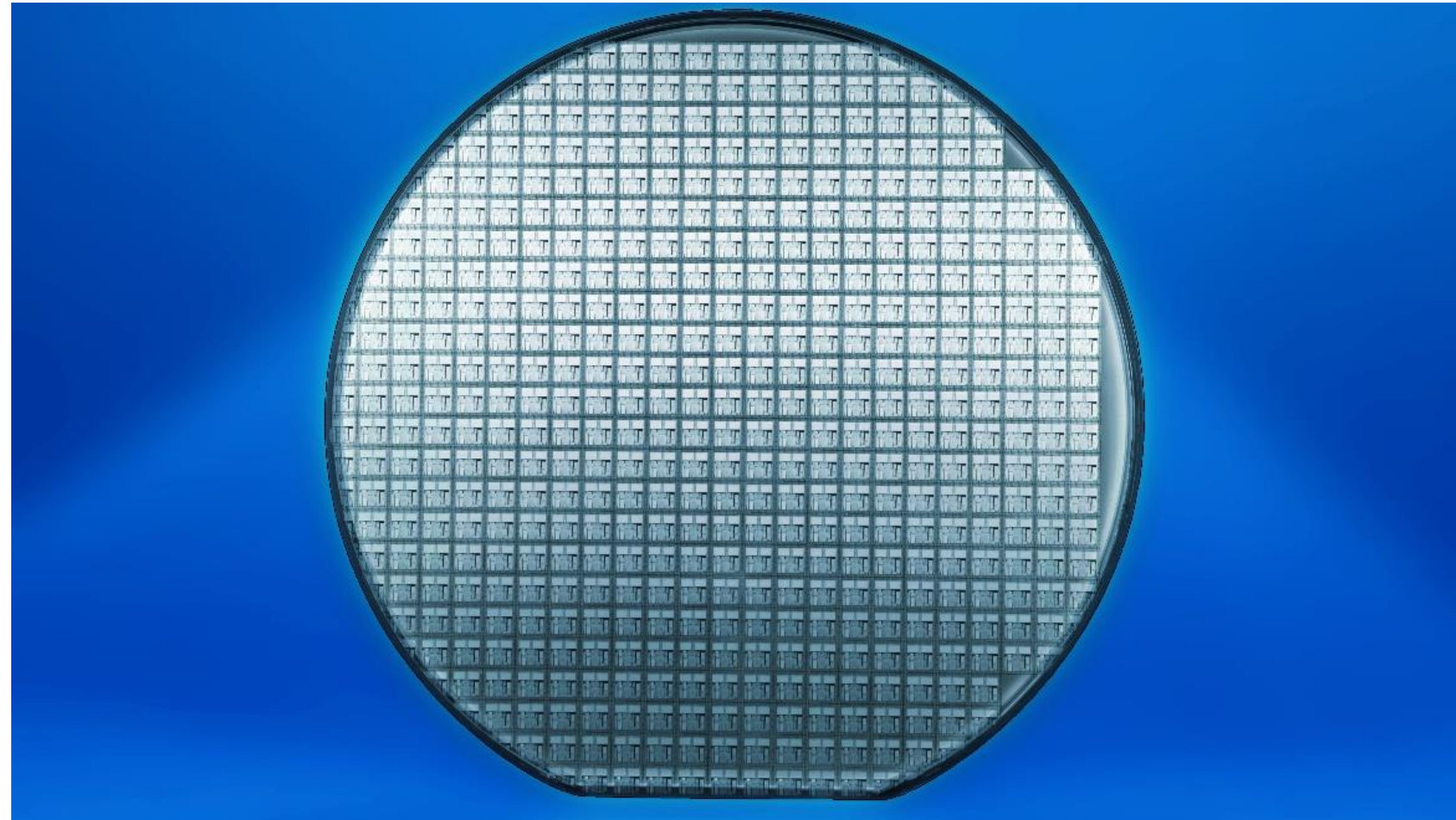
FemtoGLASS outperforms other glass dicing methods



	Blade	Stealth laser	Laser ablation	WOP FemtoGLASS
Glass thickness	2 – 19 mm	200 μ m – 10 mm	30 μ m – 2 mm	30 μ m – 2 mm in a single pass
Glass type	All types	Non-tempered Sapphire	All types	Tempered Non-tempered Sapphire
Cutting speed	up to 100 mm/s	Up to 300 mm/s	Up to 10 mm/s	Up to 800 mm/s
Possible shapes	Straight cuts only	T-shapes and circular shapes are possible	Any shape	Any shape possible
Surface chipping	< 200 μ m	< 50 μ m	< 50 μ m	< 10 μ m
Street requirement	> 50 μ m	< 15 μ m	> 50 μ m	< 1 μ m
Water (cooling/cleaning)	yes	no	yes	no
Debris	yes	no	yes	no
Thermal effect on the device	yes	no	yes	no



Where to apply?

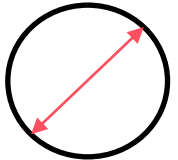


- Wafer level glass product dicing
- Augmented reality, smart glasses screens
- Mobile phone screens, camera lenses
- Micro optics elements
- Thin glass
- Electronic components
- Display technologies

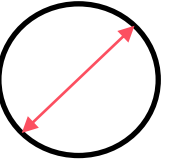
All kind of holes in glass

— 25 μm

Glass drilling



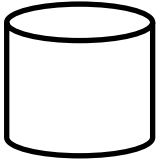
Hole diameter
from 20 μm



Hole size tolerance
 $\pm 1 \mu\text{m}$



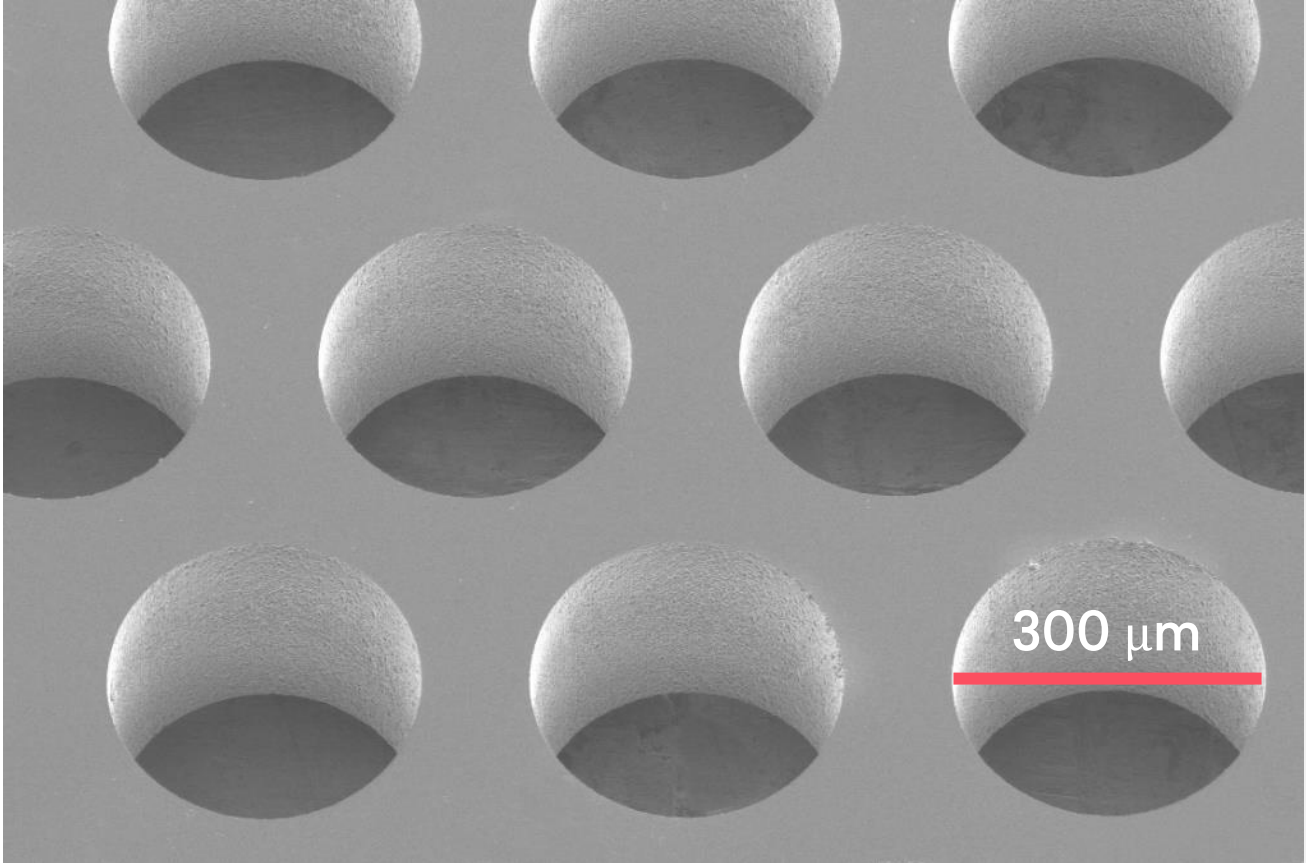
Aspect ratio
To 1:100



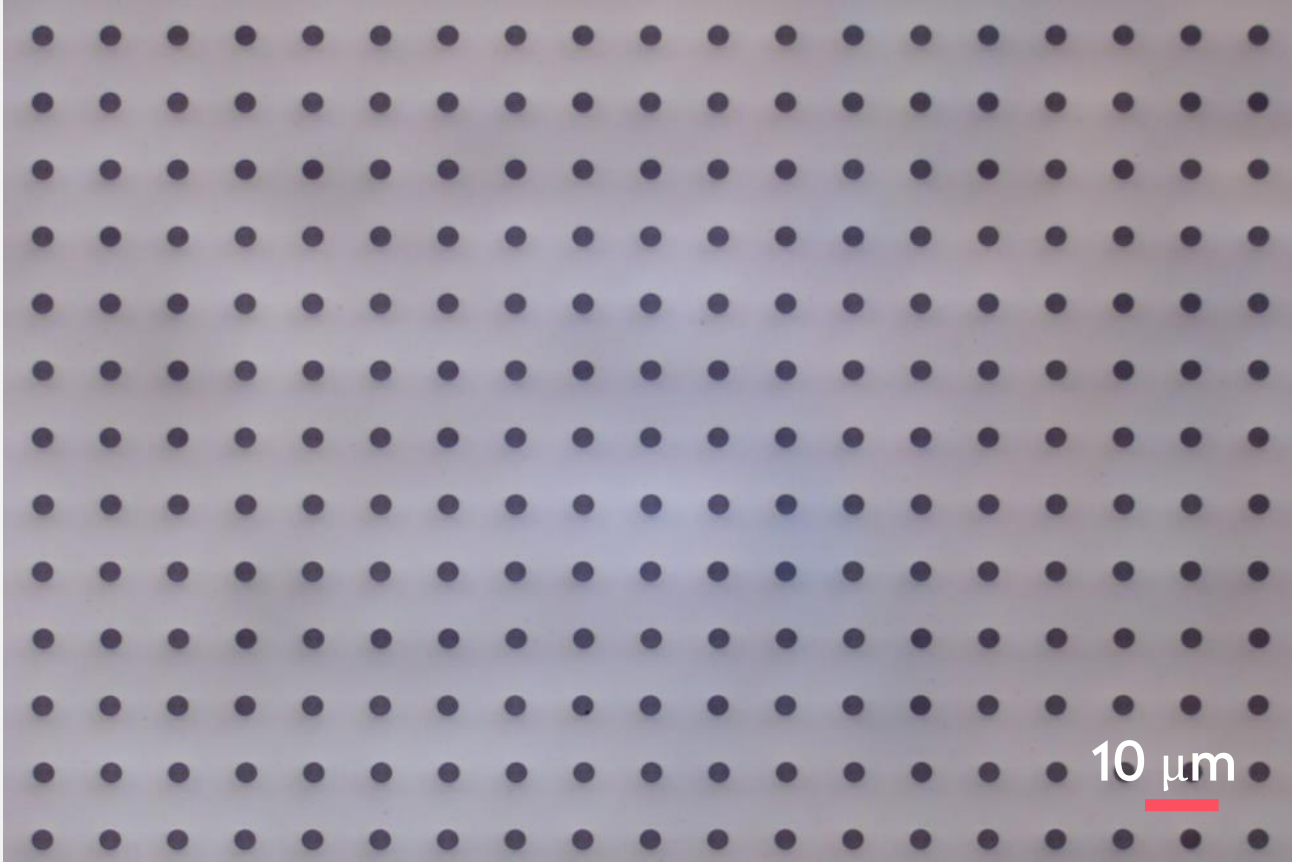
Smooth sidewalls
 $Ra < 1 \mu\text{m}$



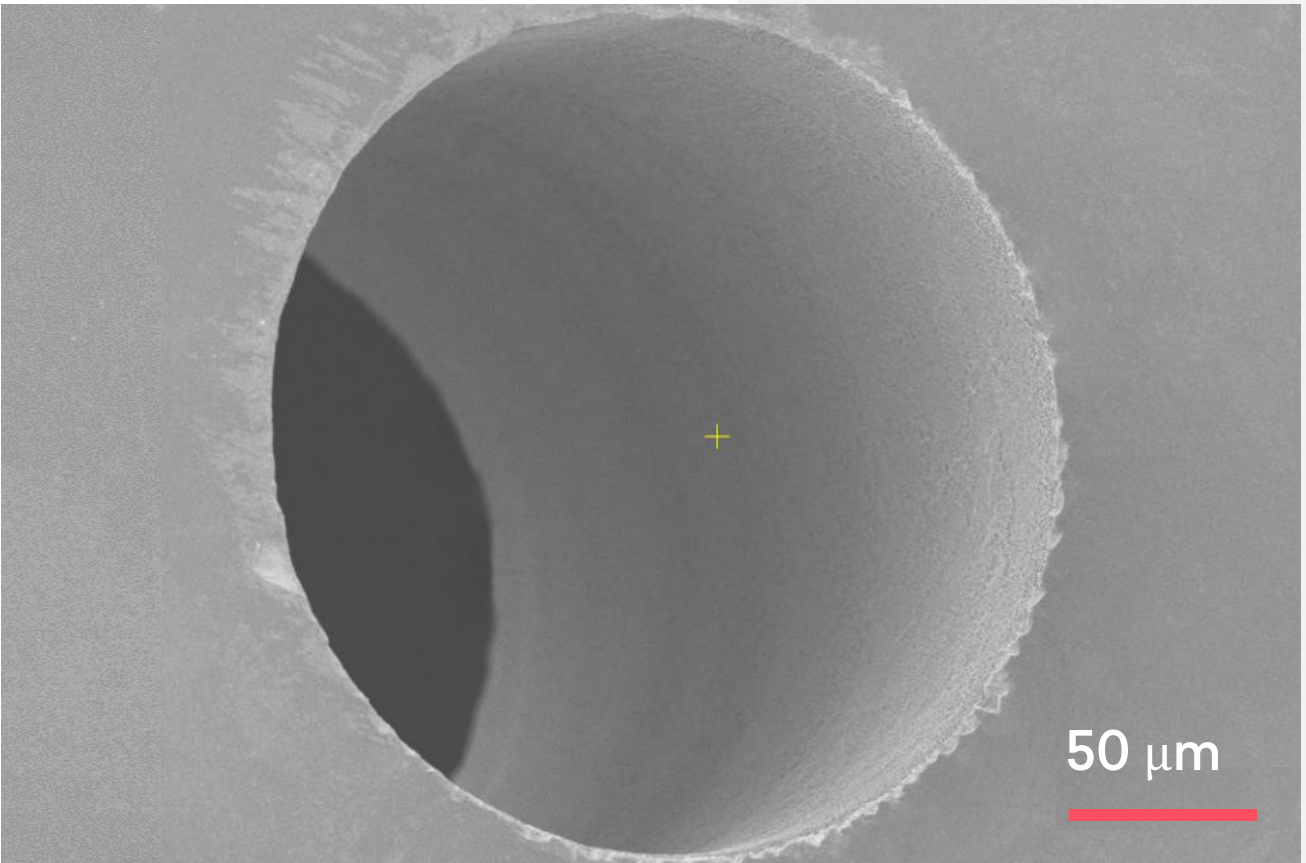
Holes drilled
per 1 minute
65 000 +



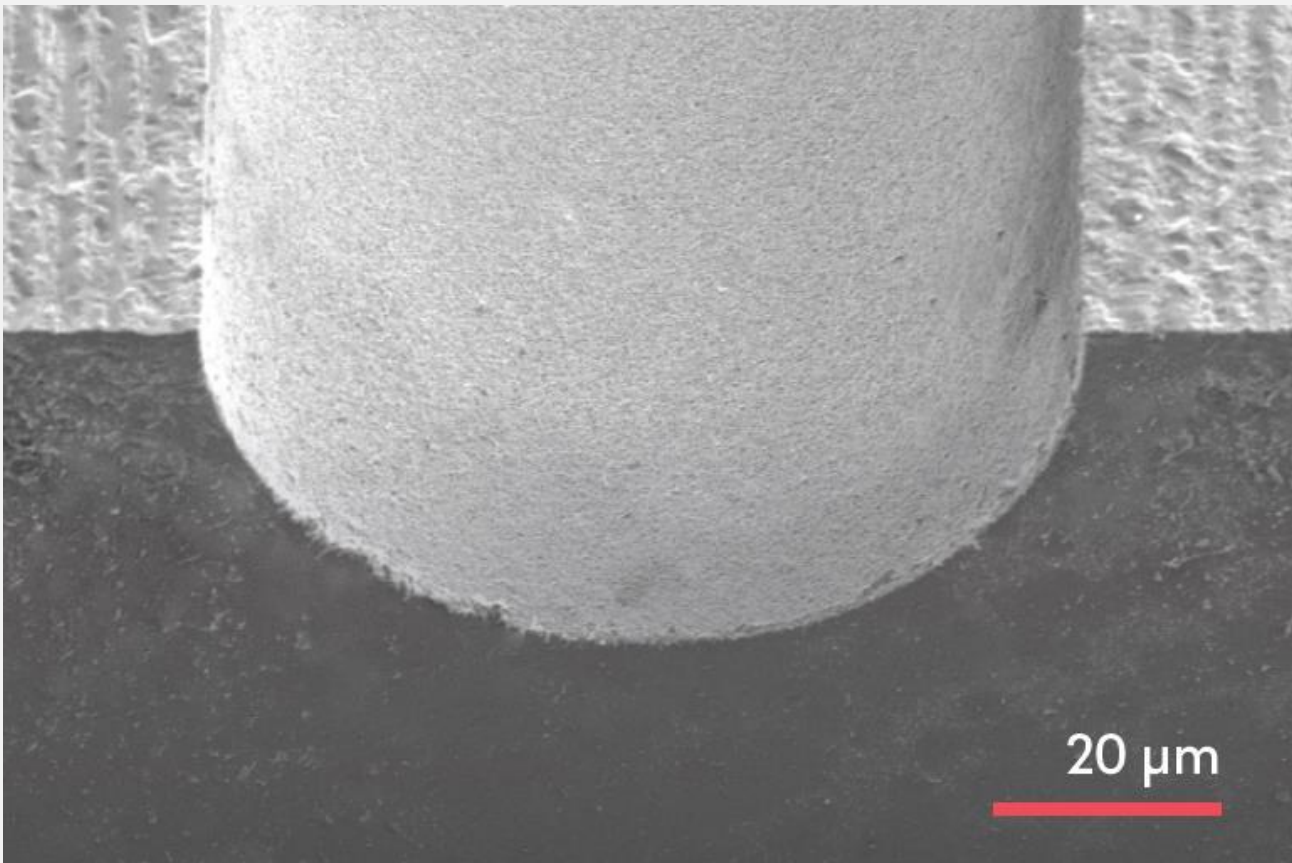
SEM images of vertical wall hole array



3 million holes in 8" diameter, 500 μm thickness fused silica wafer



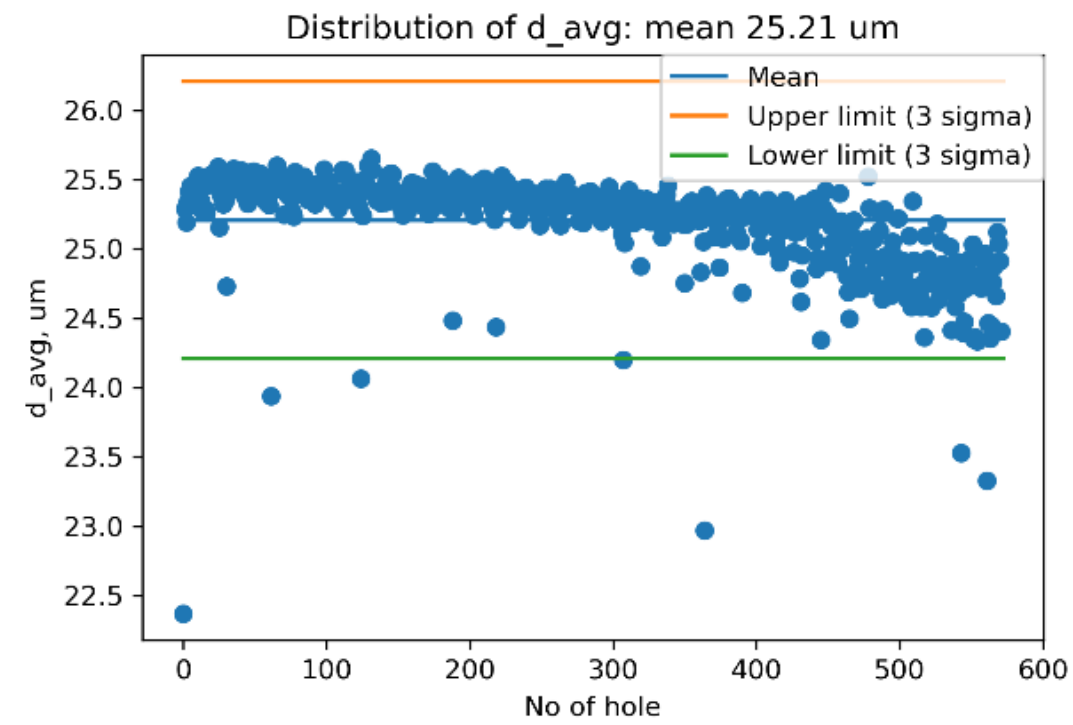
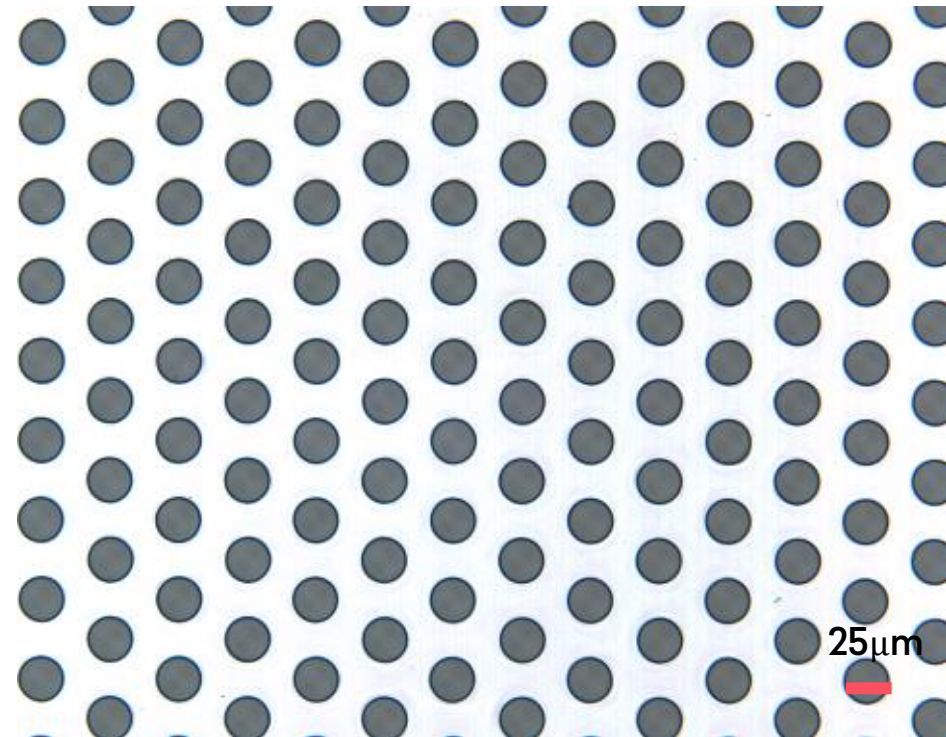
Obsidian (SiO_2) micro drilling without taper



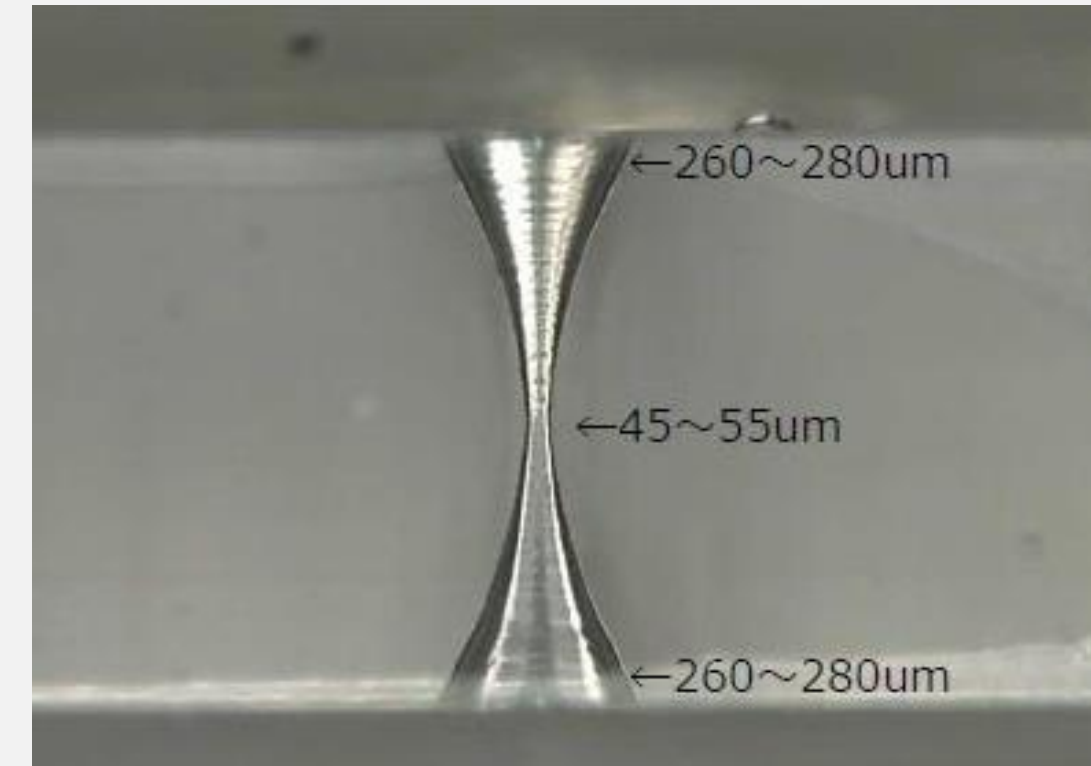
Sapphire drilling top view

More drilling

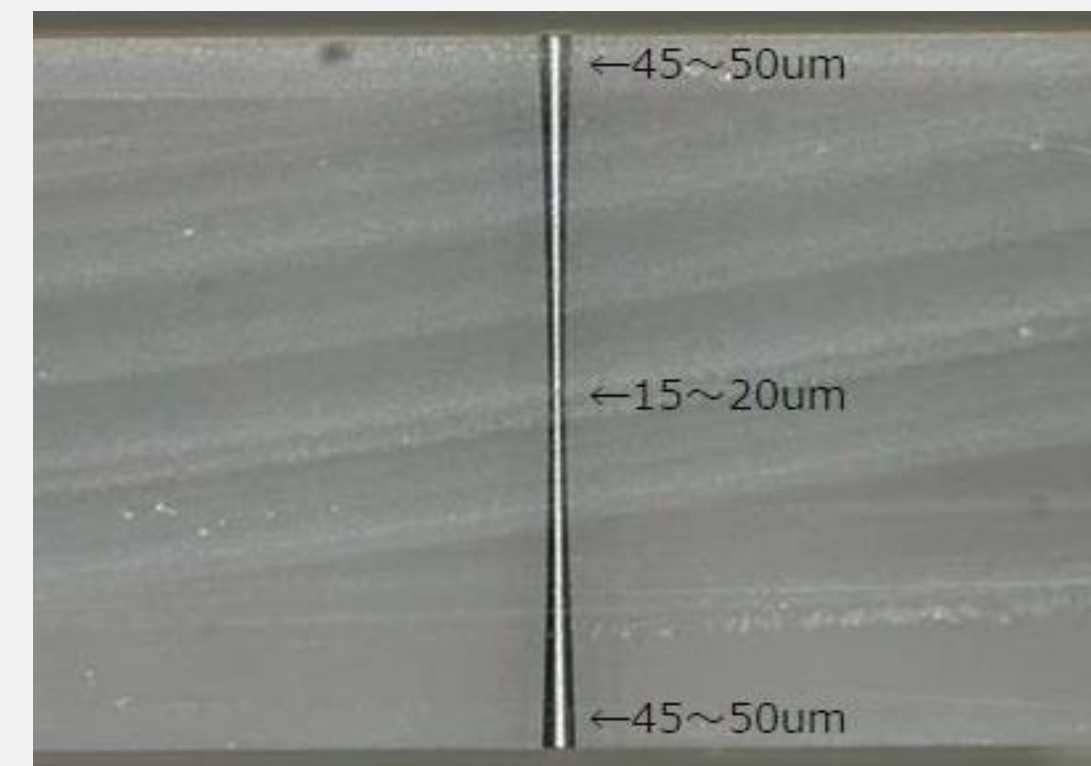
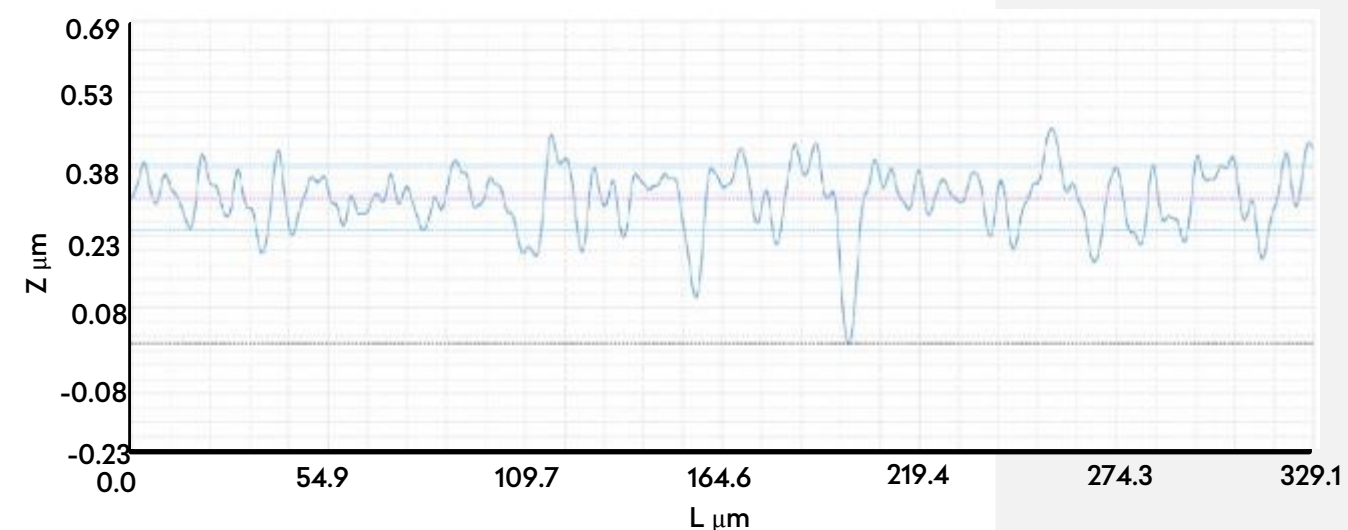
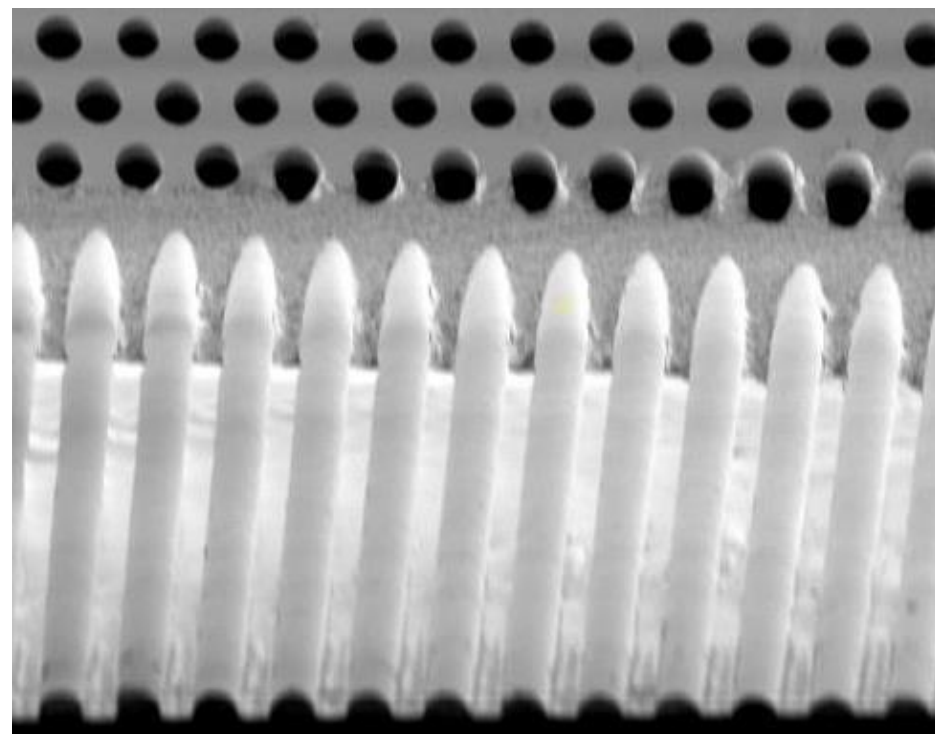
99% identical diameter holes



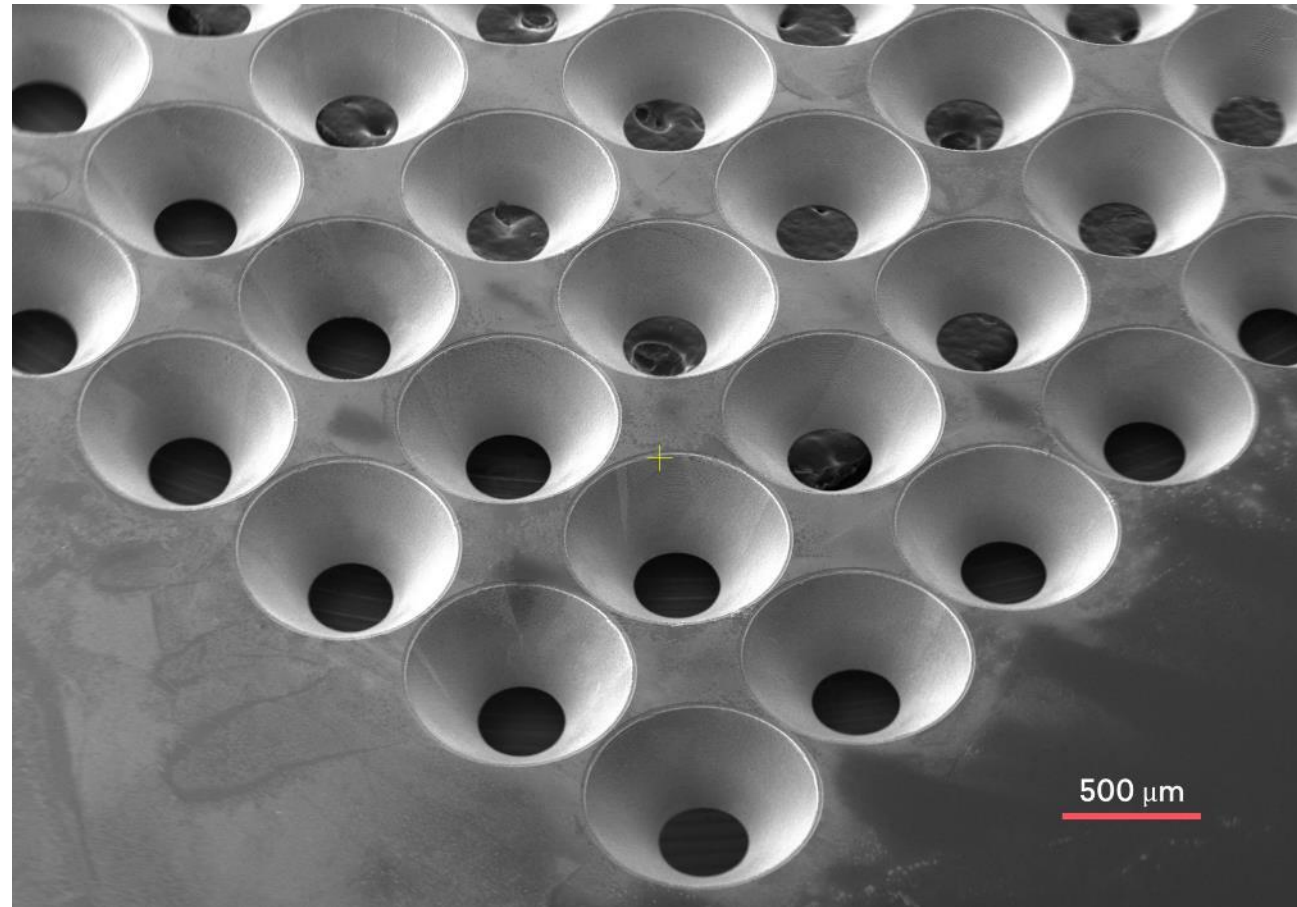
Hole shape: hourglass



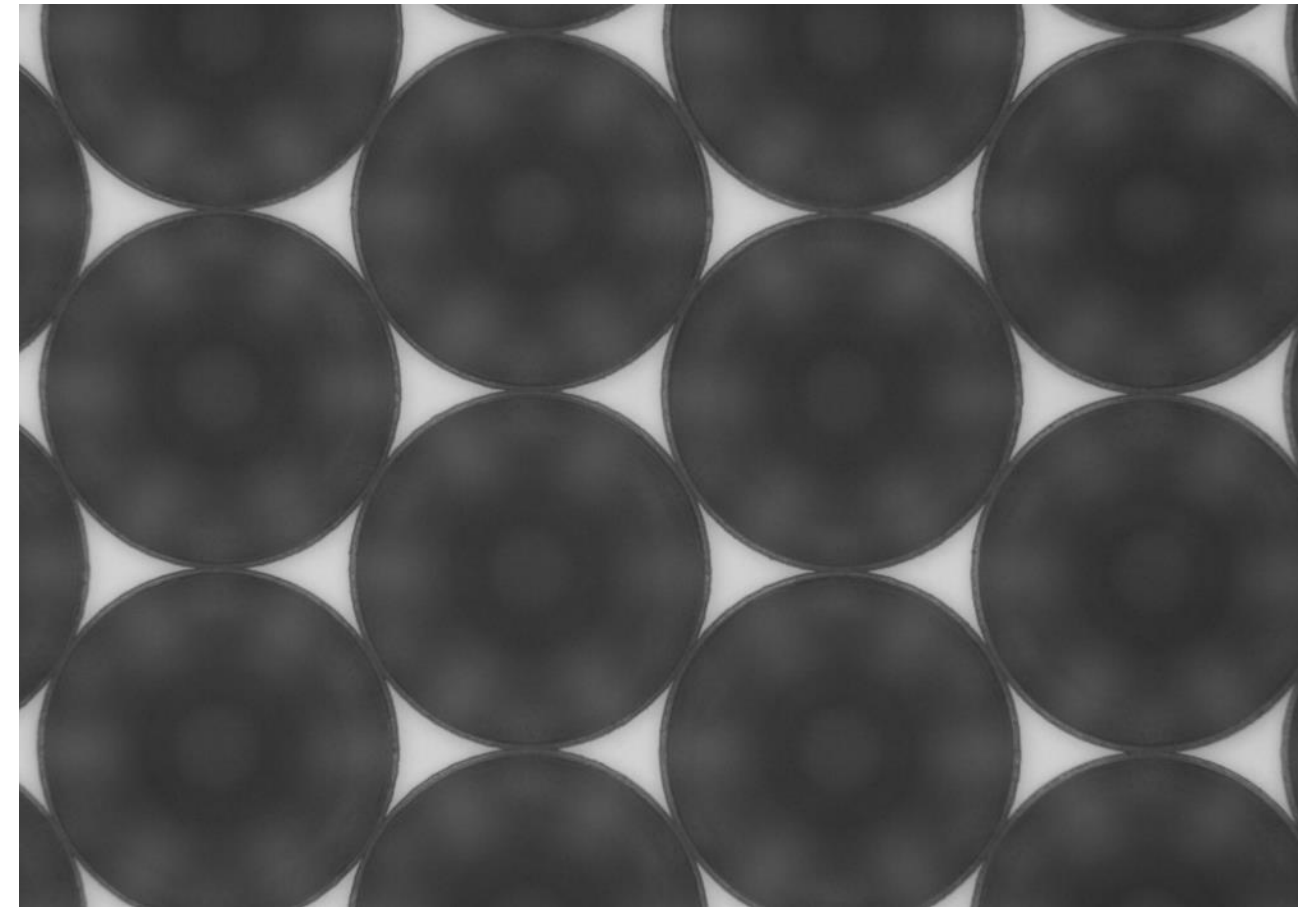
Ra < 0.08 μm: super smooth sidewalls



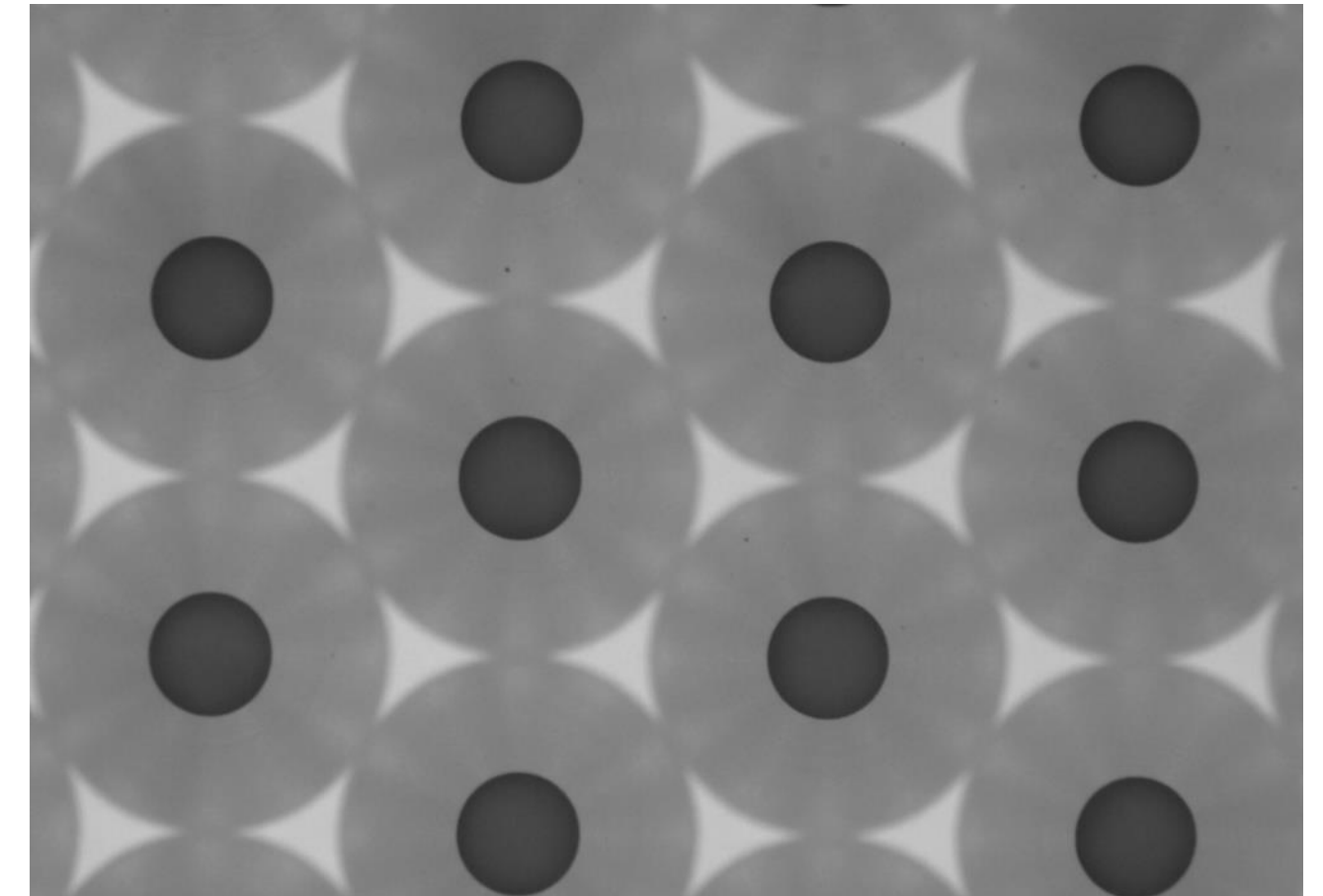
Tapered holes



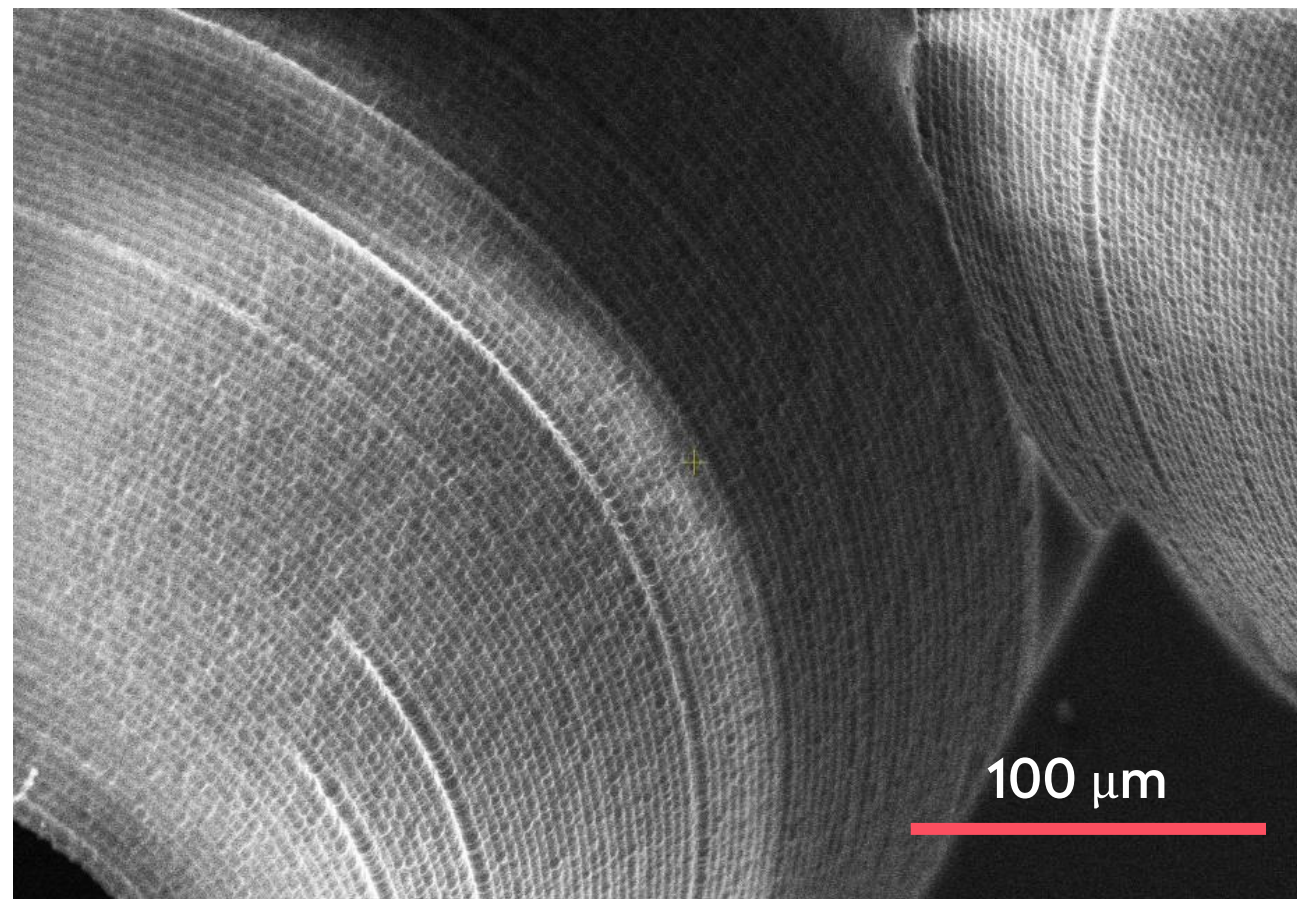
SEM images of tapered holes



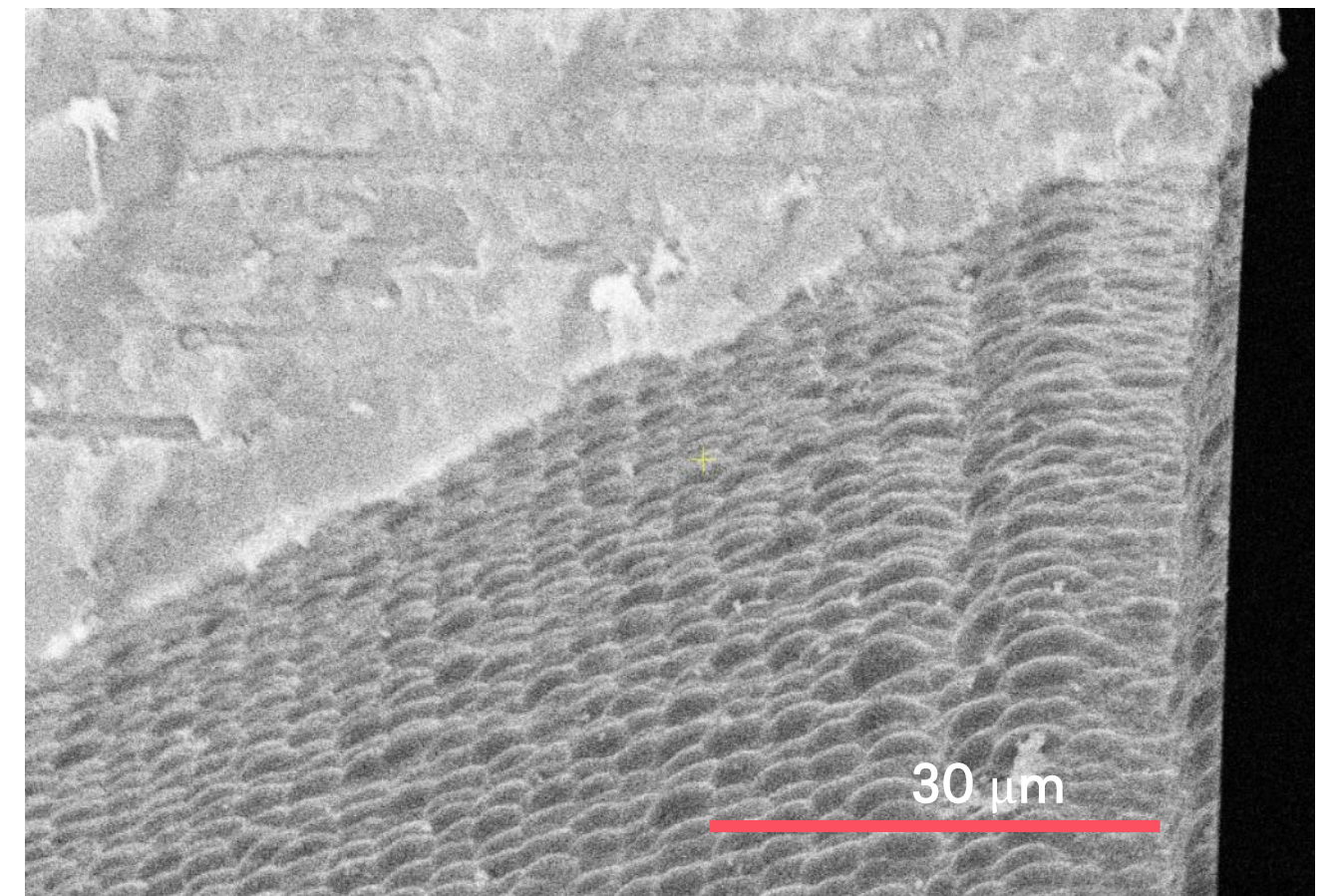
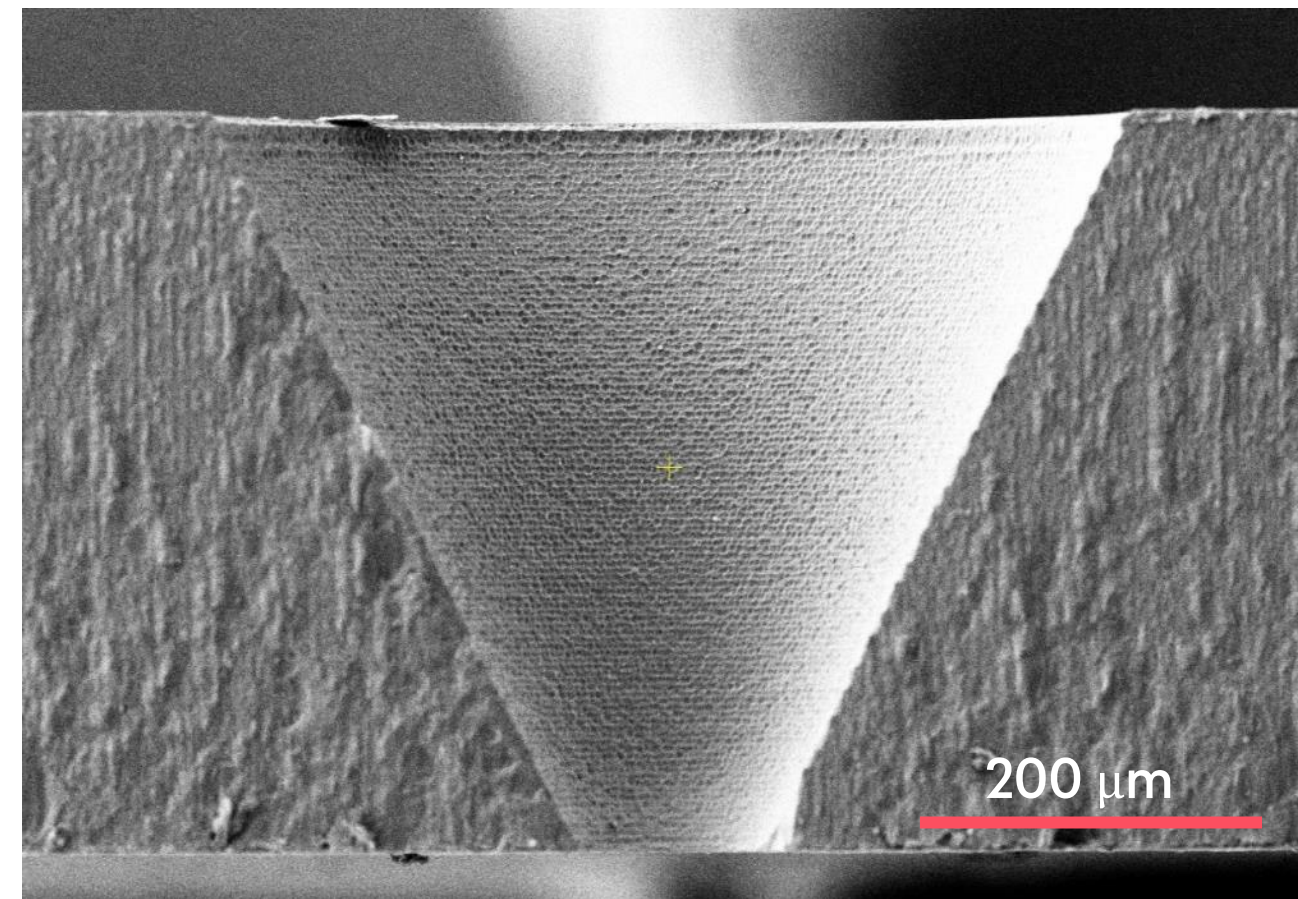
Entry 5x



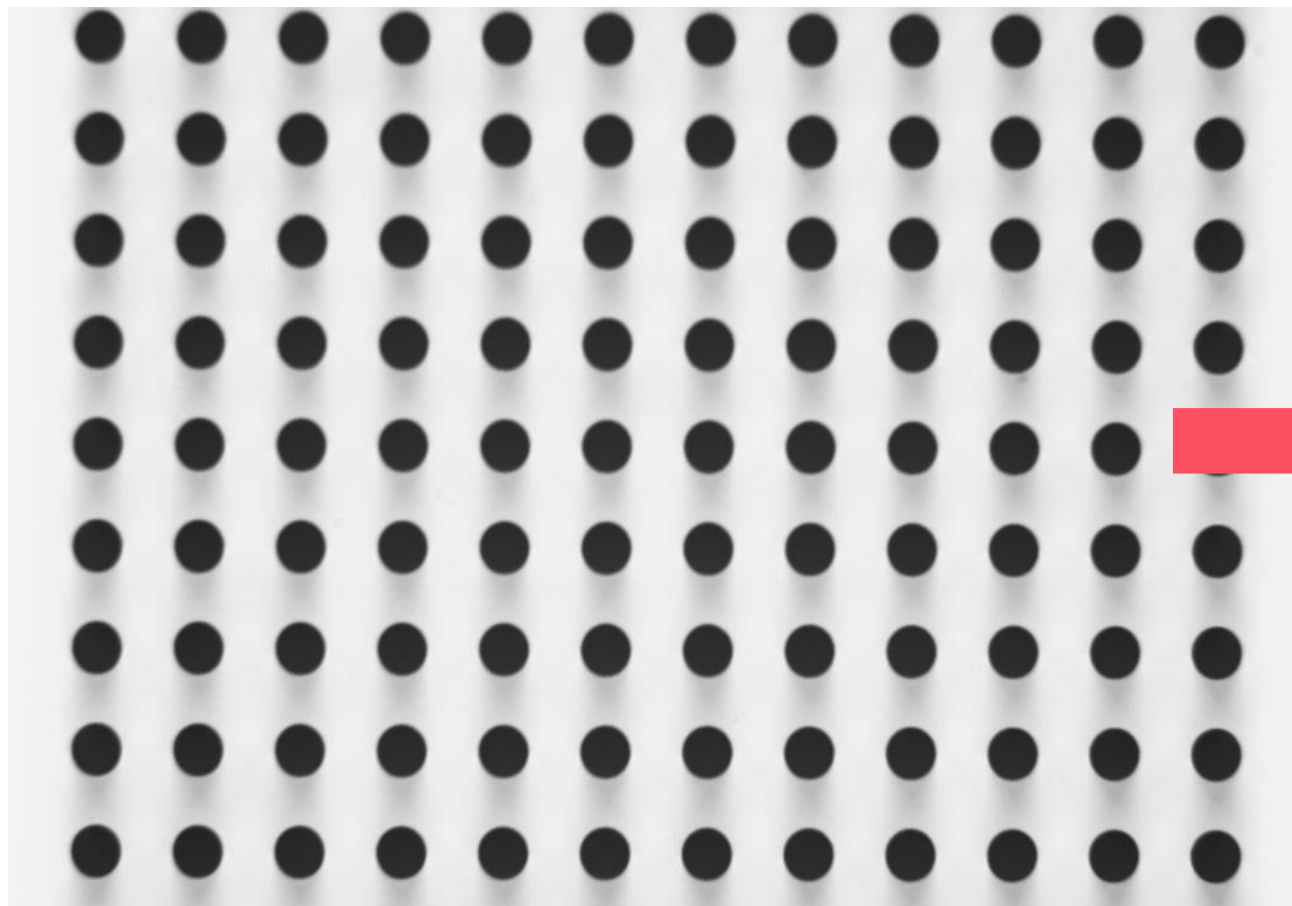
Exit 5x



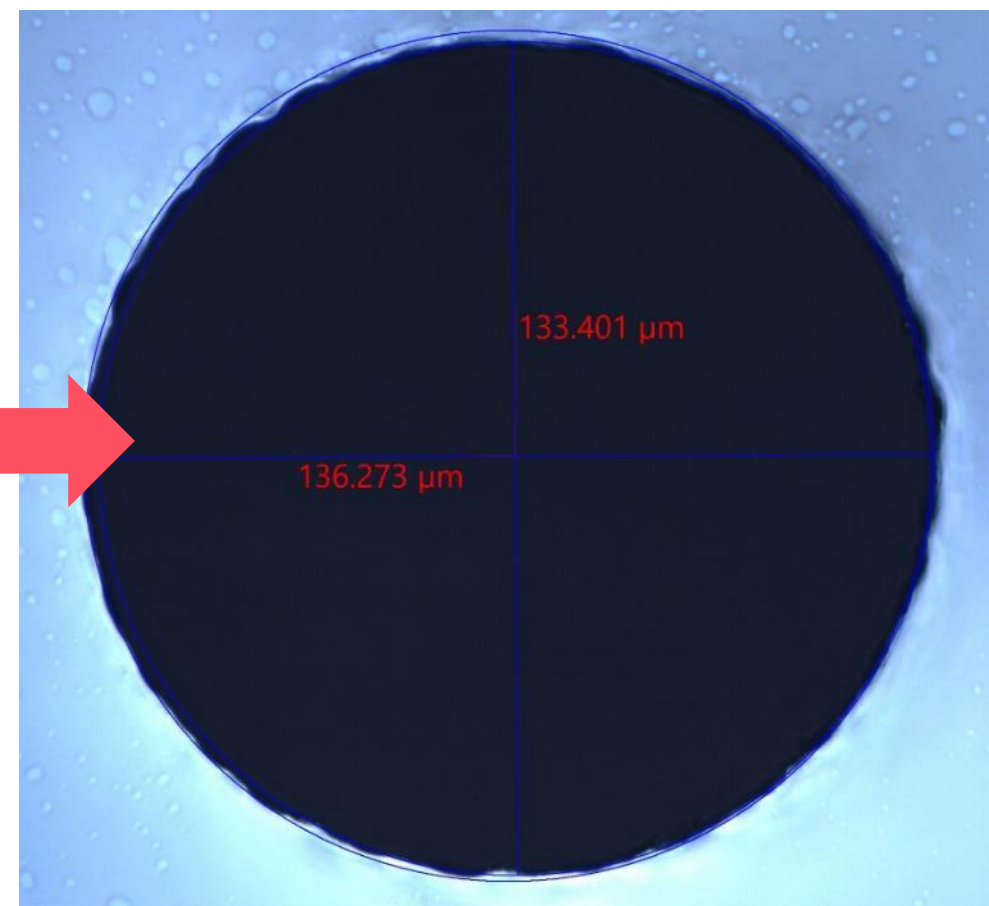
SEM images of tapered holes



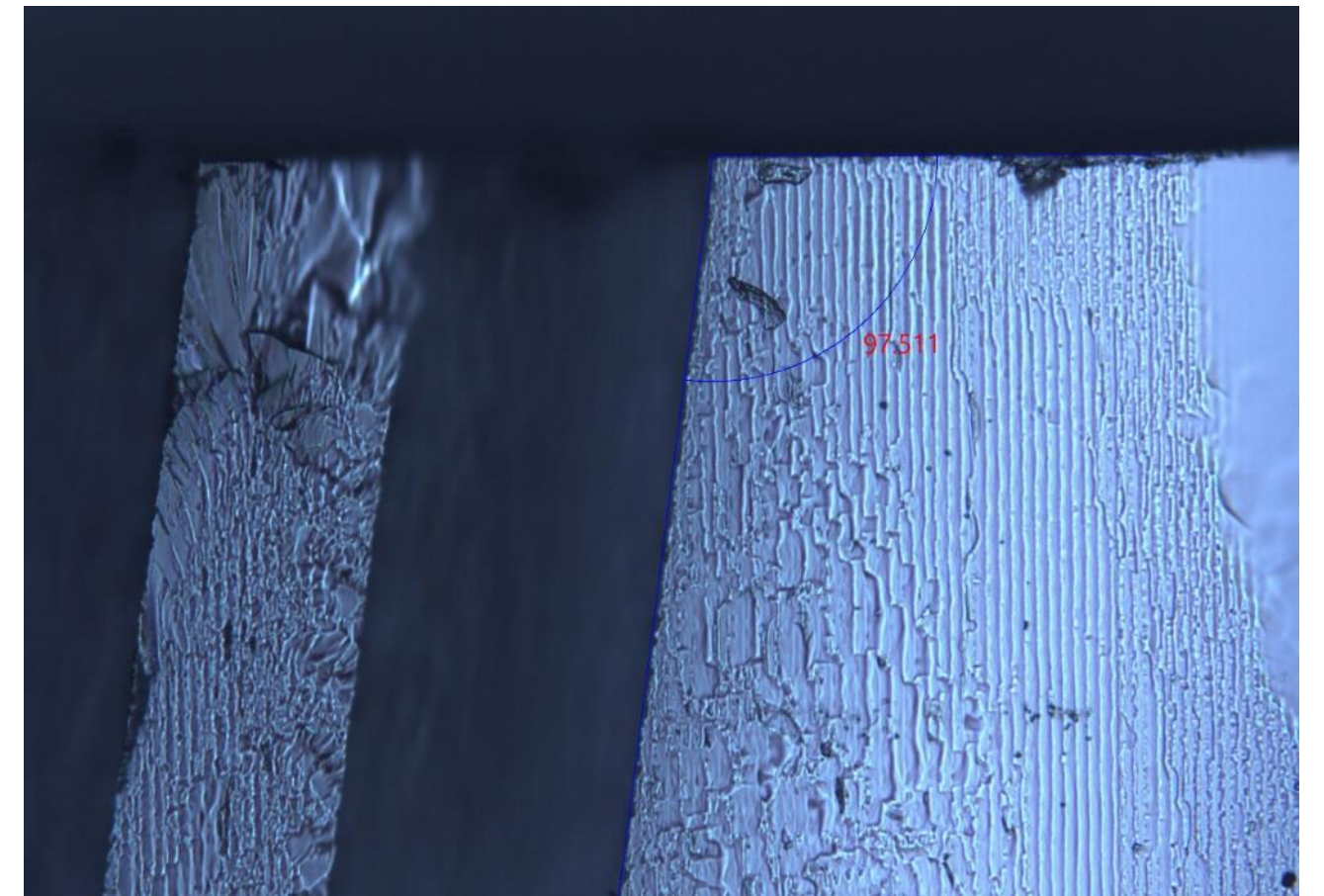
Angled hole arrays



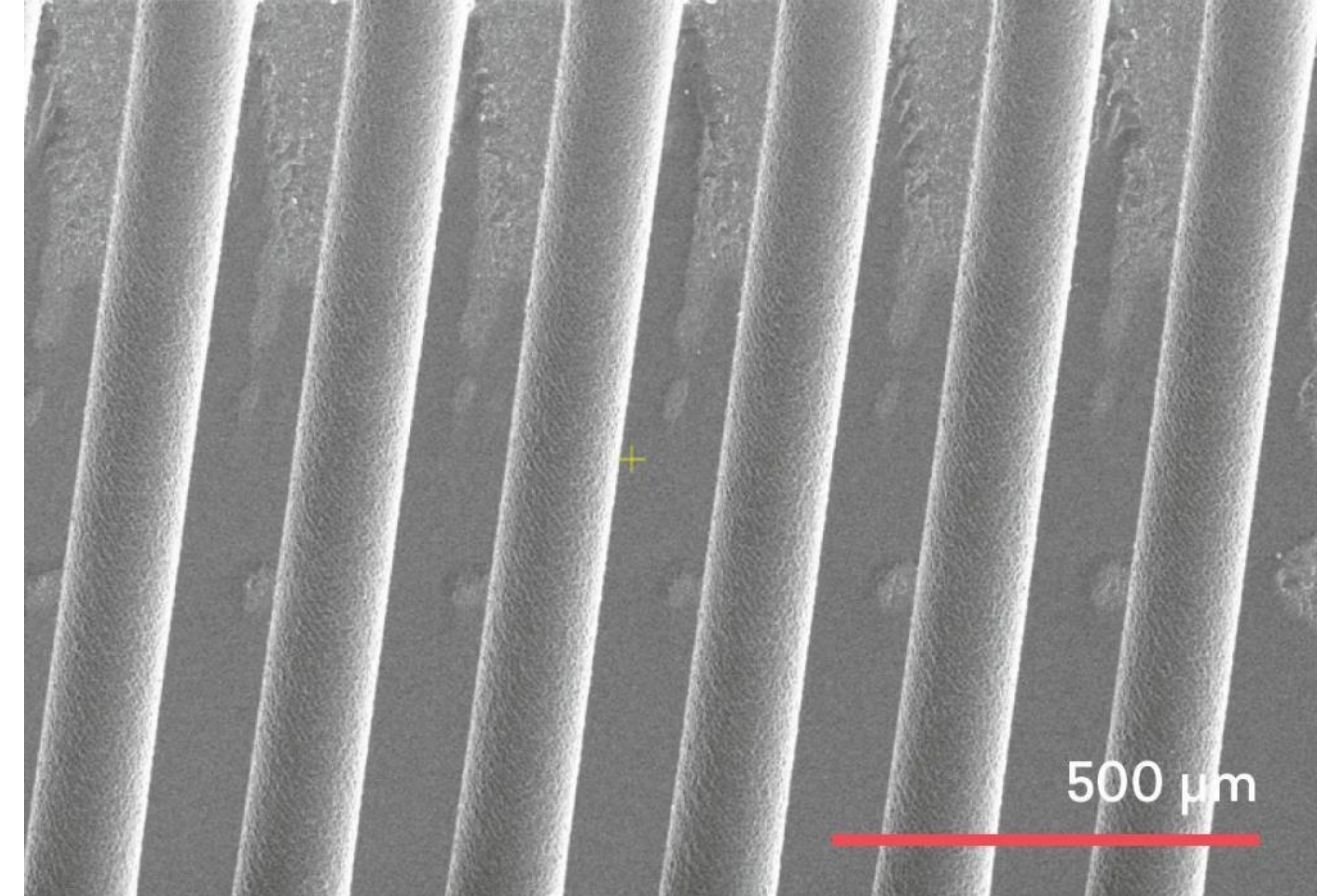
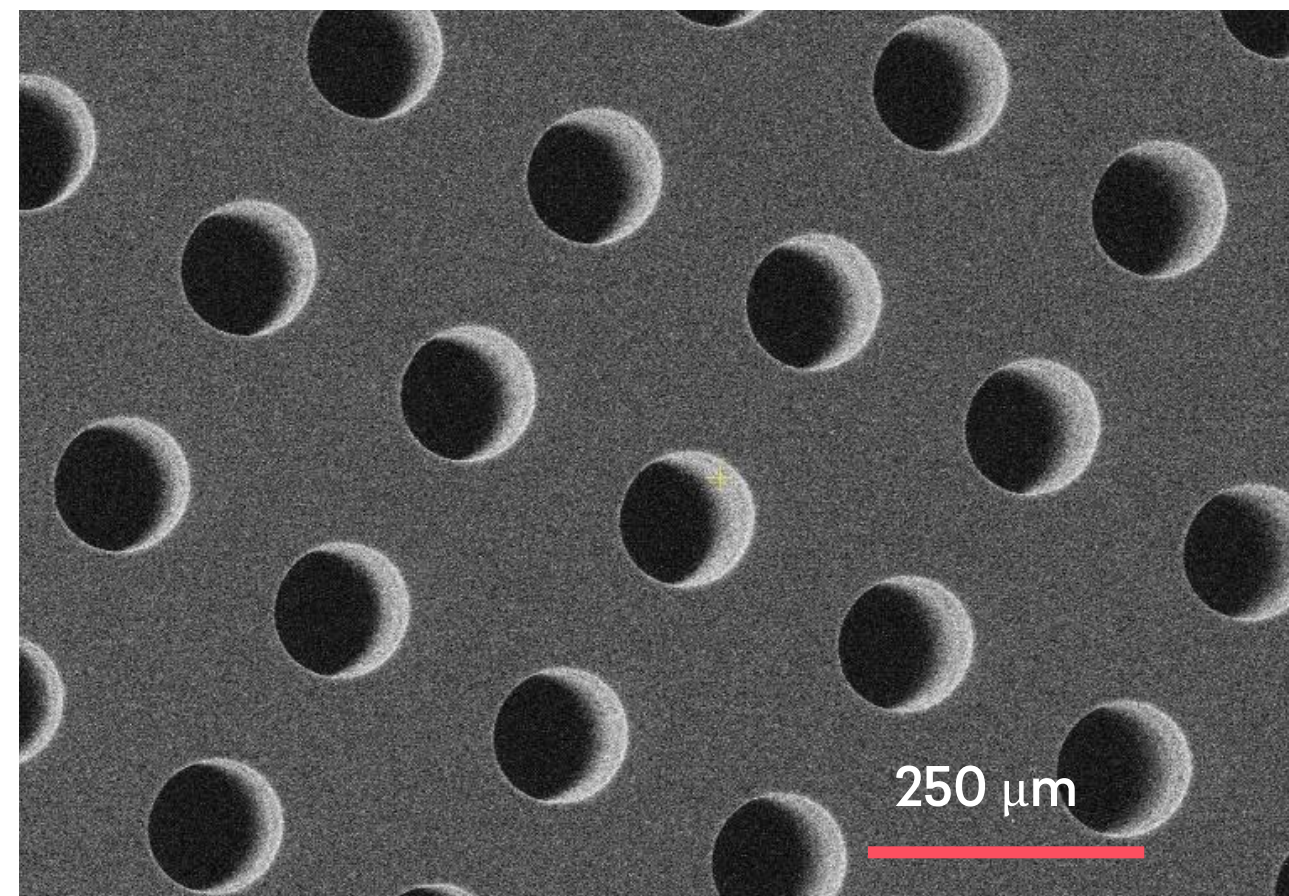
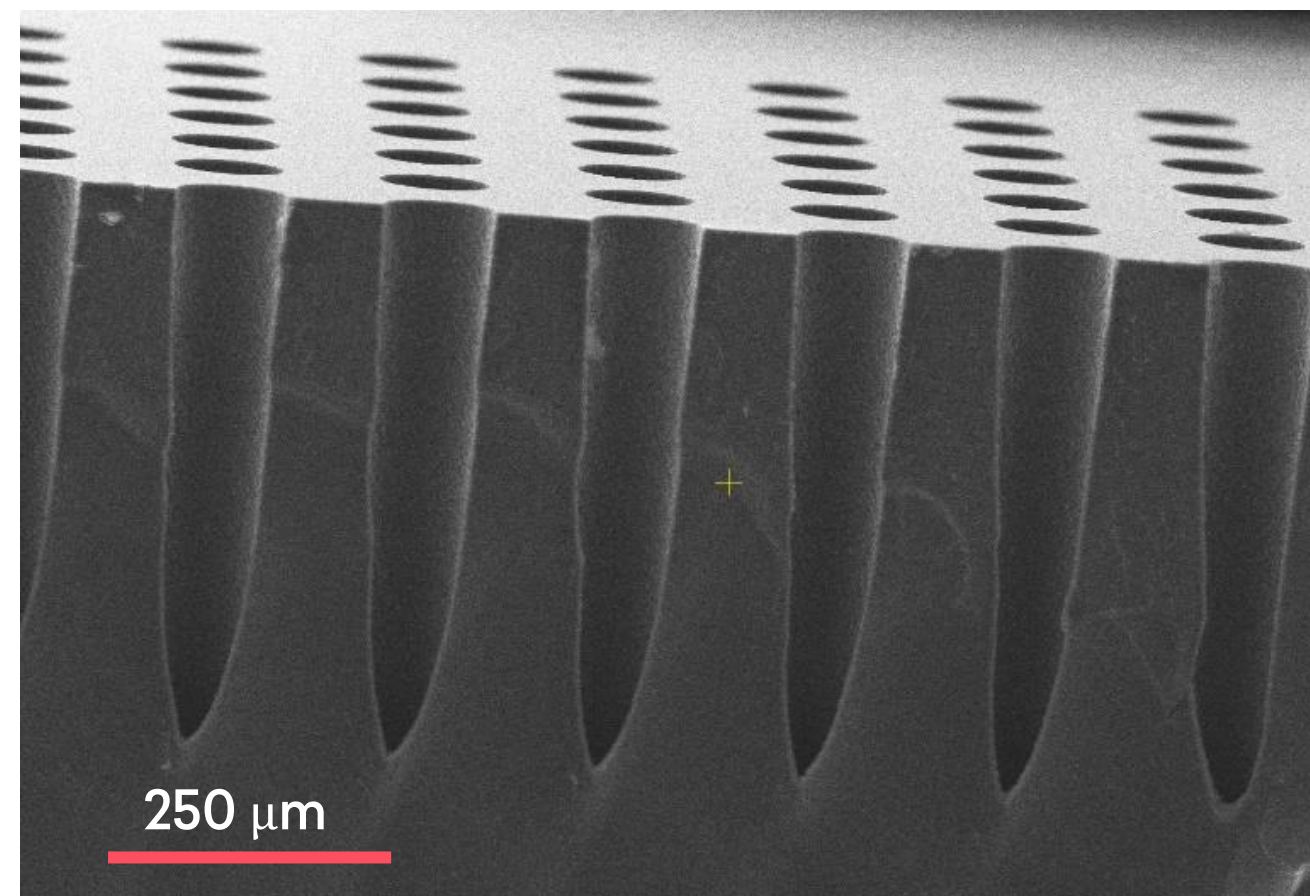
Entry 5x



Entry, 50x



Side view, 20x



Side view, 10x

SLE | Selective laser etching

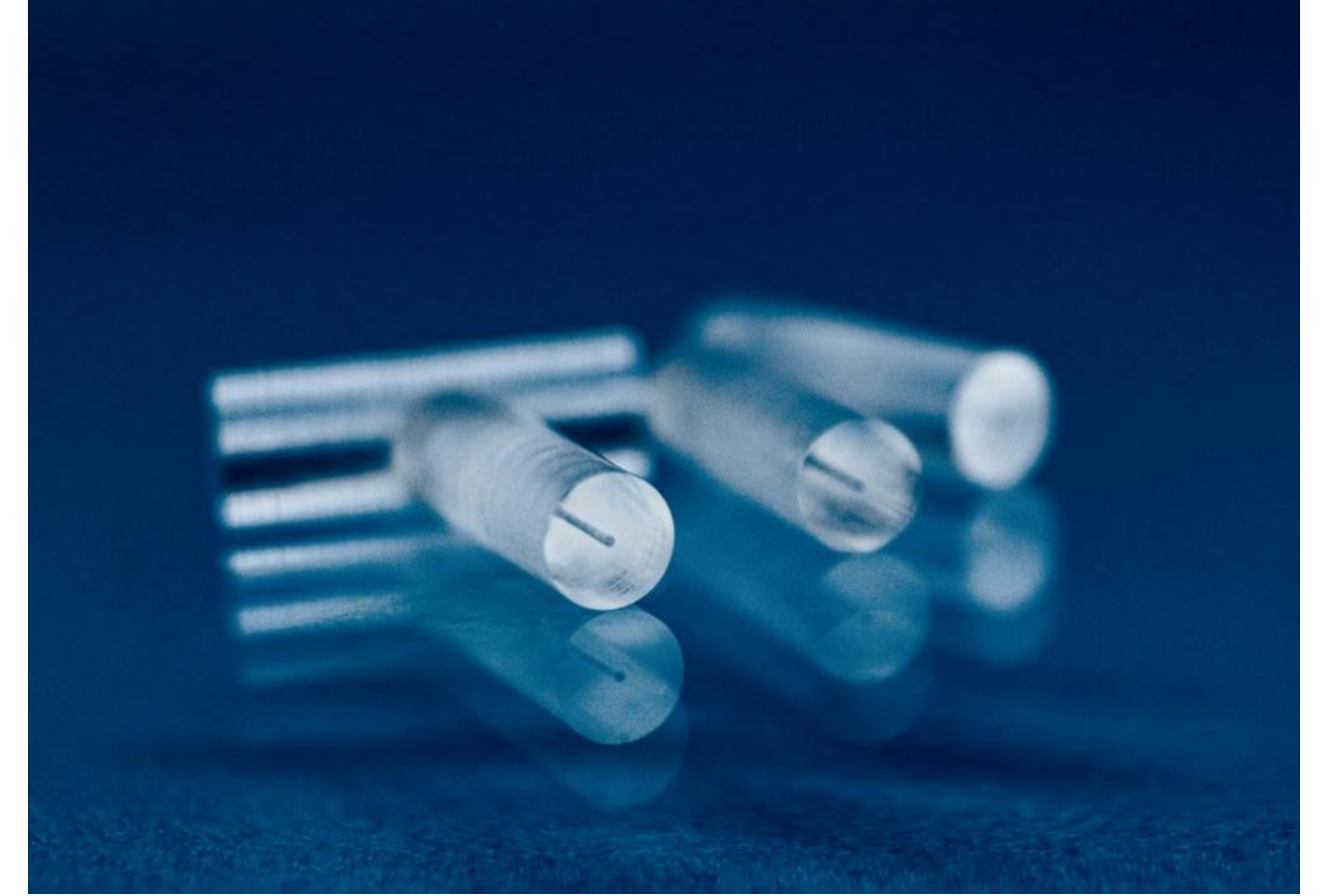
SLE technology ensures **zero micro-cracks or chipping**

Various shapes:
circular, square, irregular

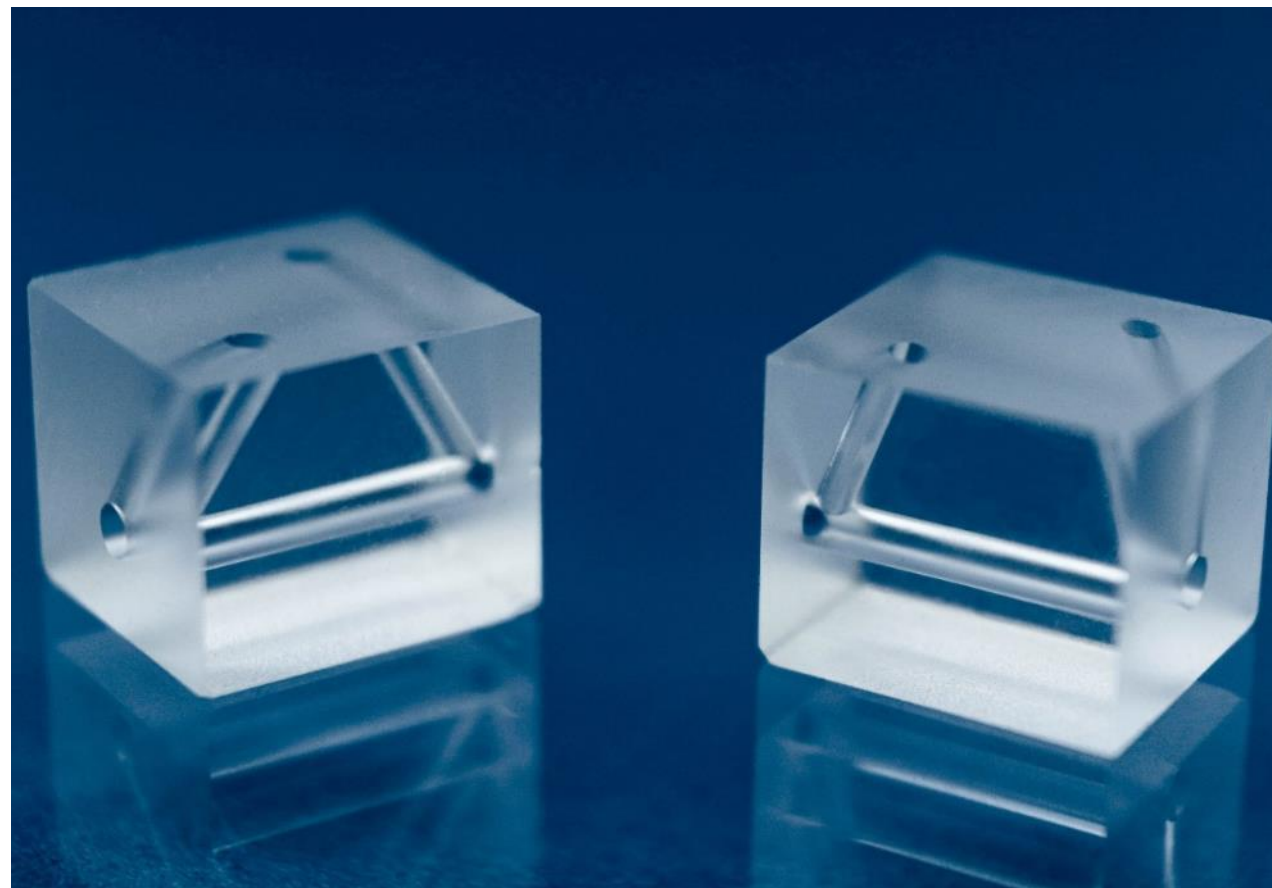
Thin glass: from 30 μm to 3 mm



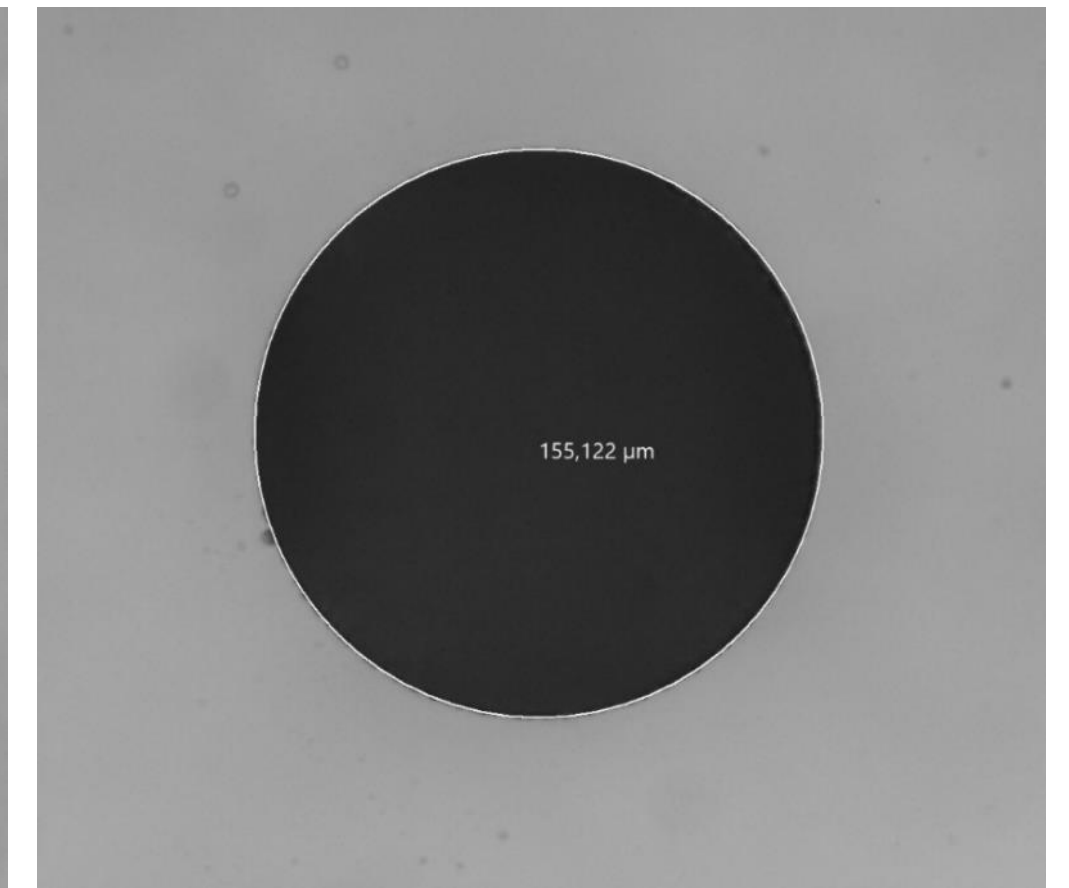
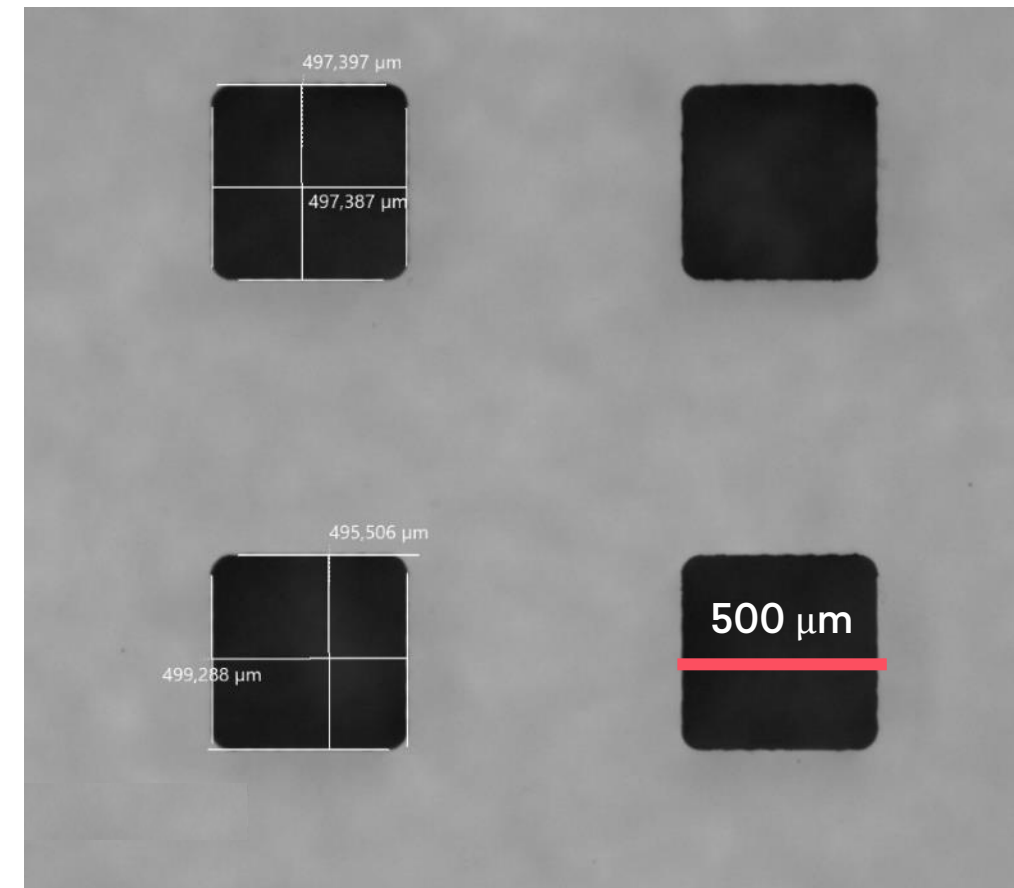
Fiber alignment arrays, with SLE



Glass rod for fiber optic collimators, ferrules, alignment fixture

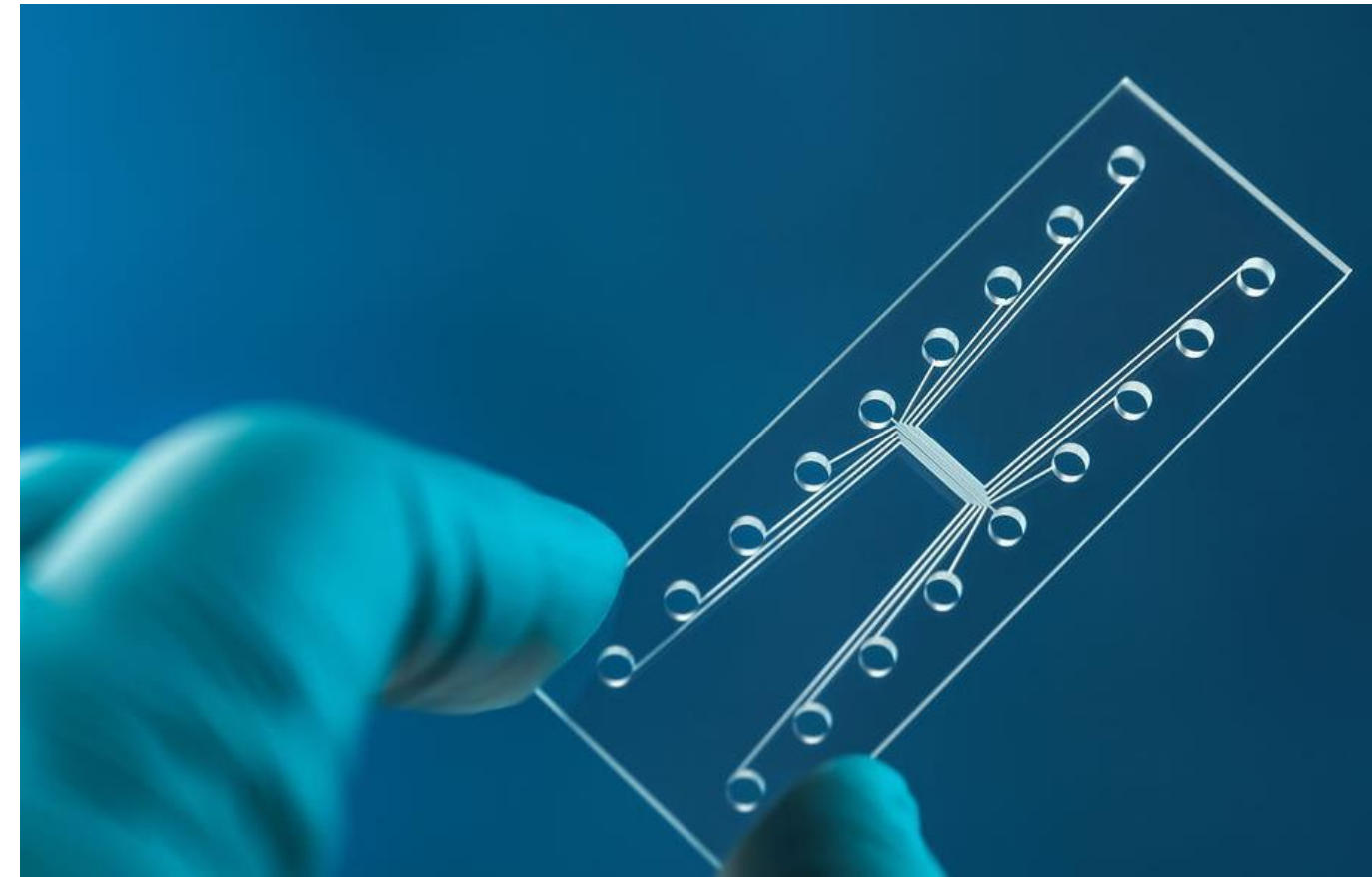


Selective laser etching for 3D glass structures

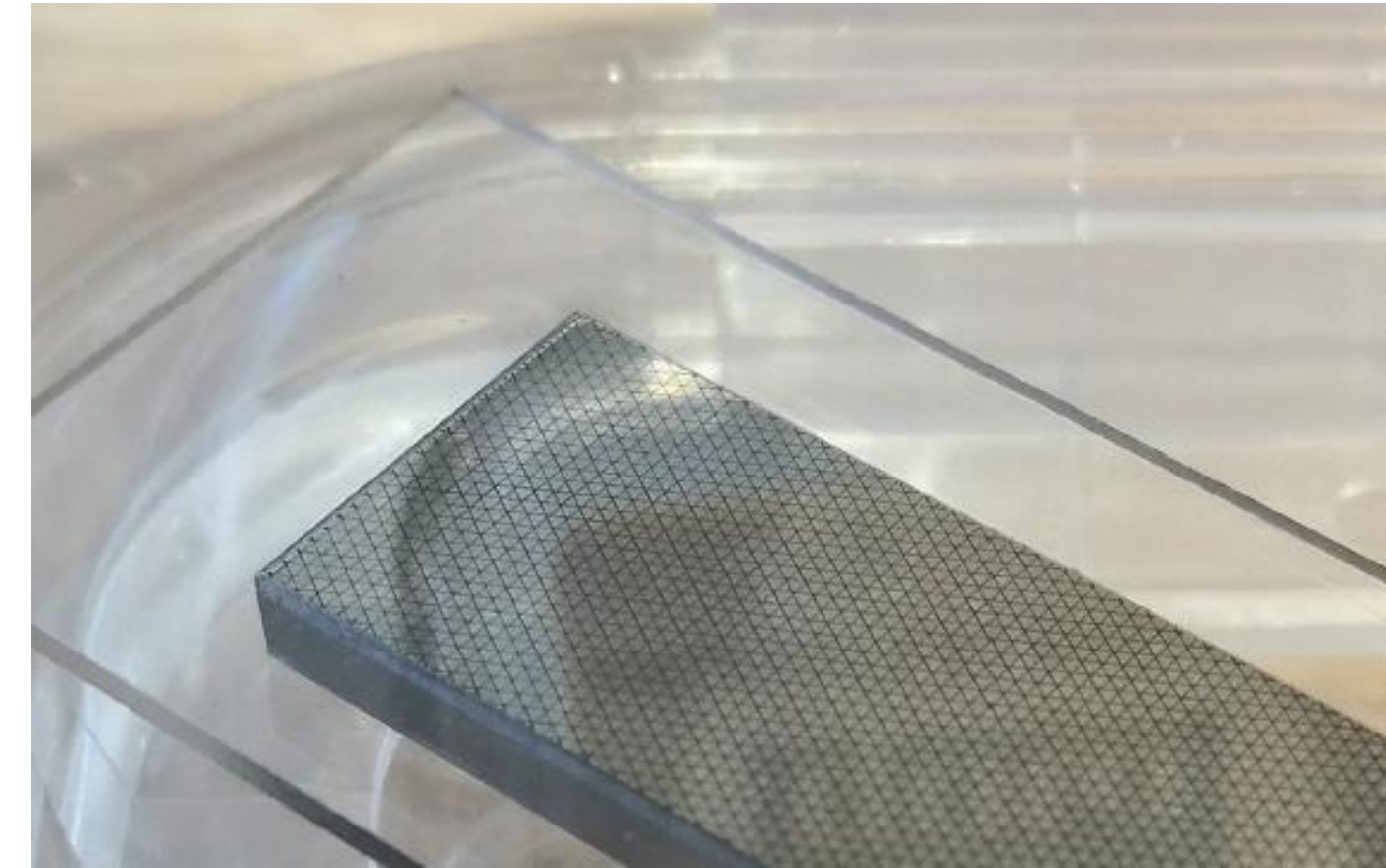


Laser welding

- High precision
- Good mechanical strength
- No extra bonding material is needed
- Hermetic sealing
- Minimum heat-affected zones



Microfluidic channels sealing



Glass to metal micro welding

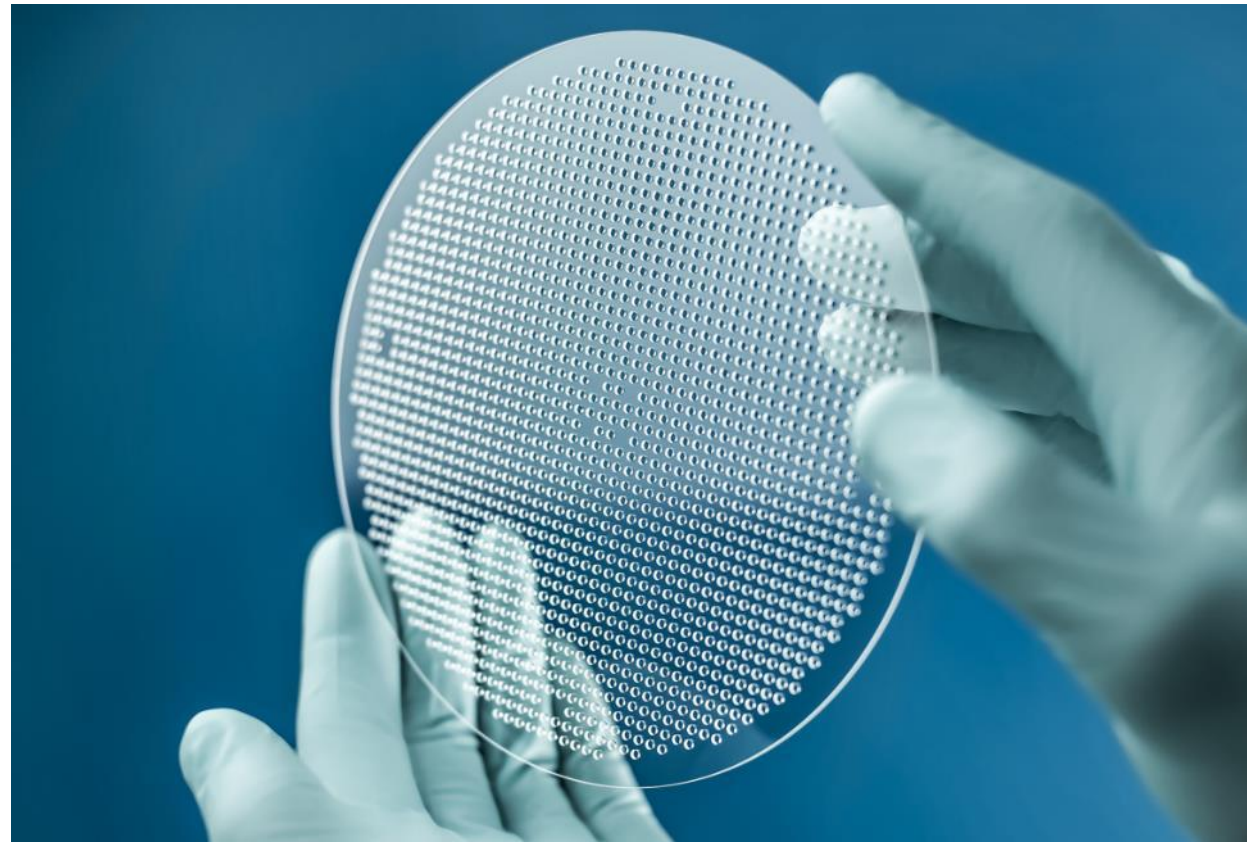


Microfluidic chip, 5 hermetic layers bonded without adhesive, side view

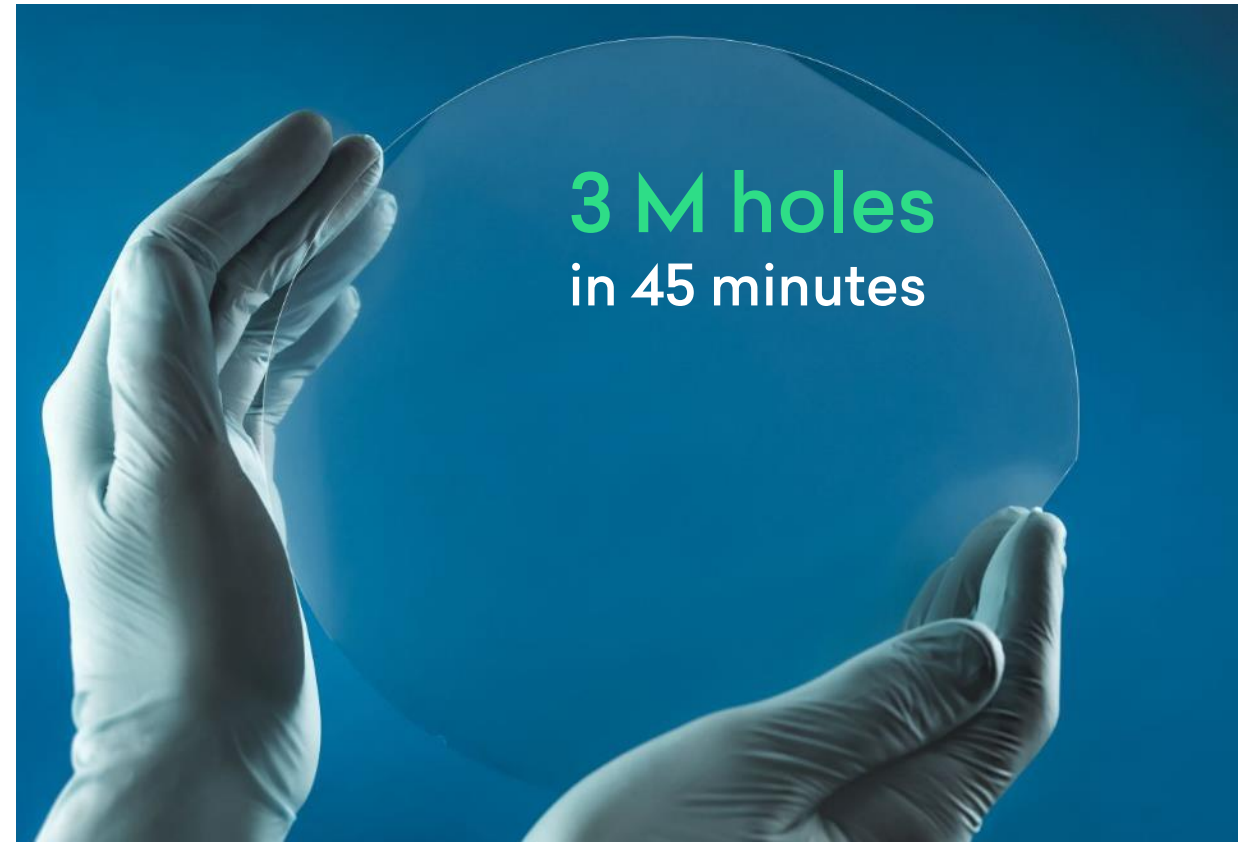


Glass to metal micro welding

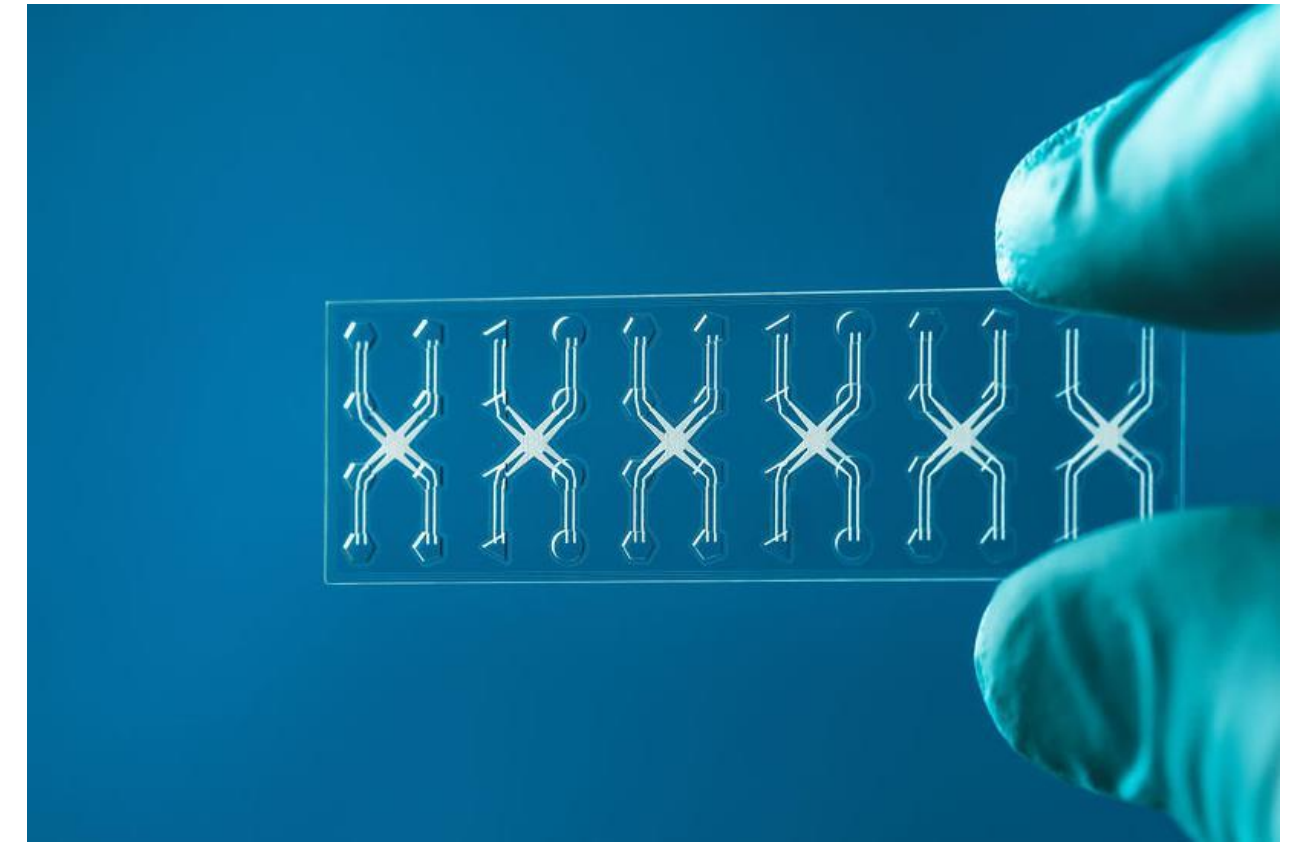
Where to apply?



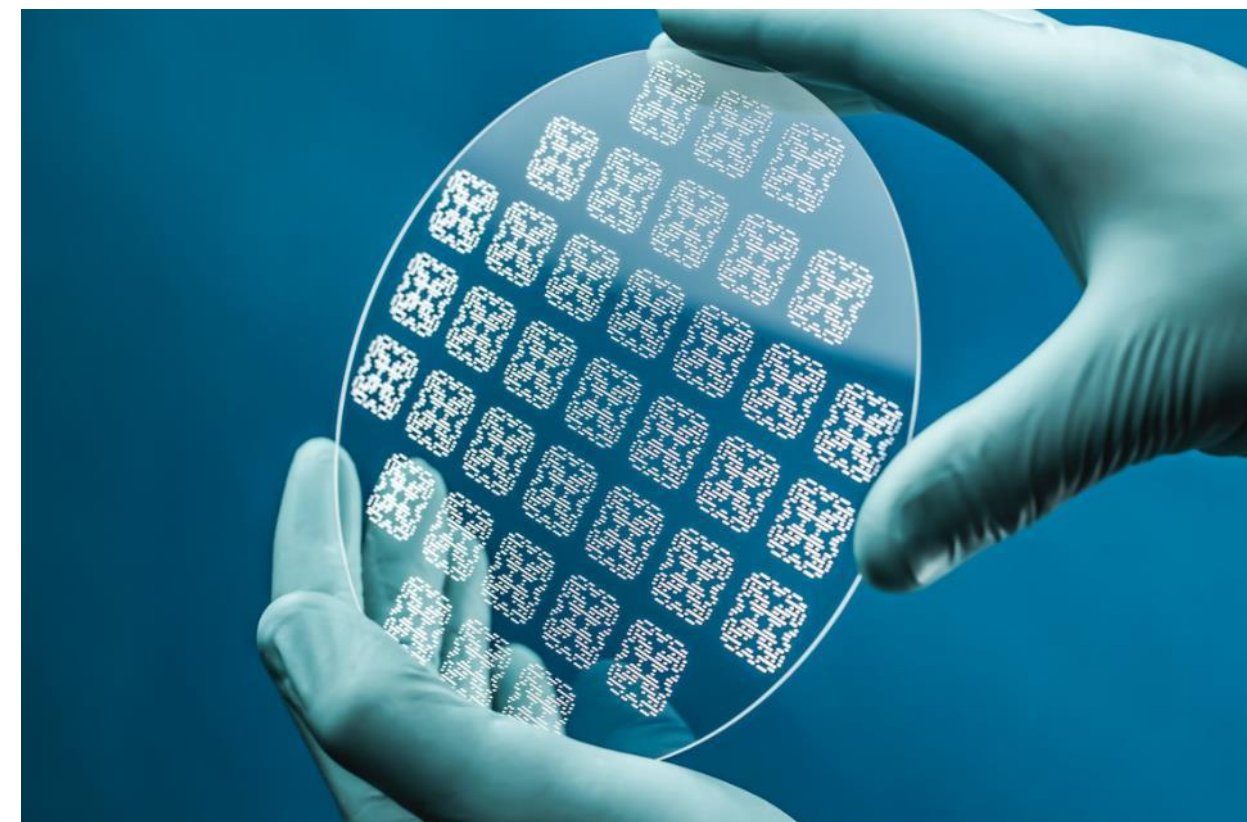
Glass spacers | Interposers



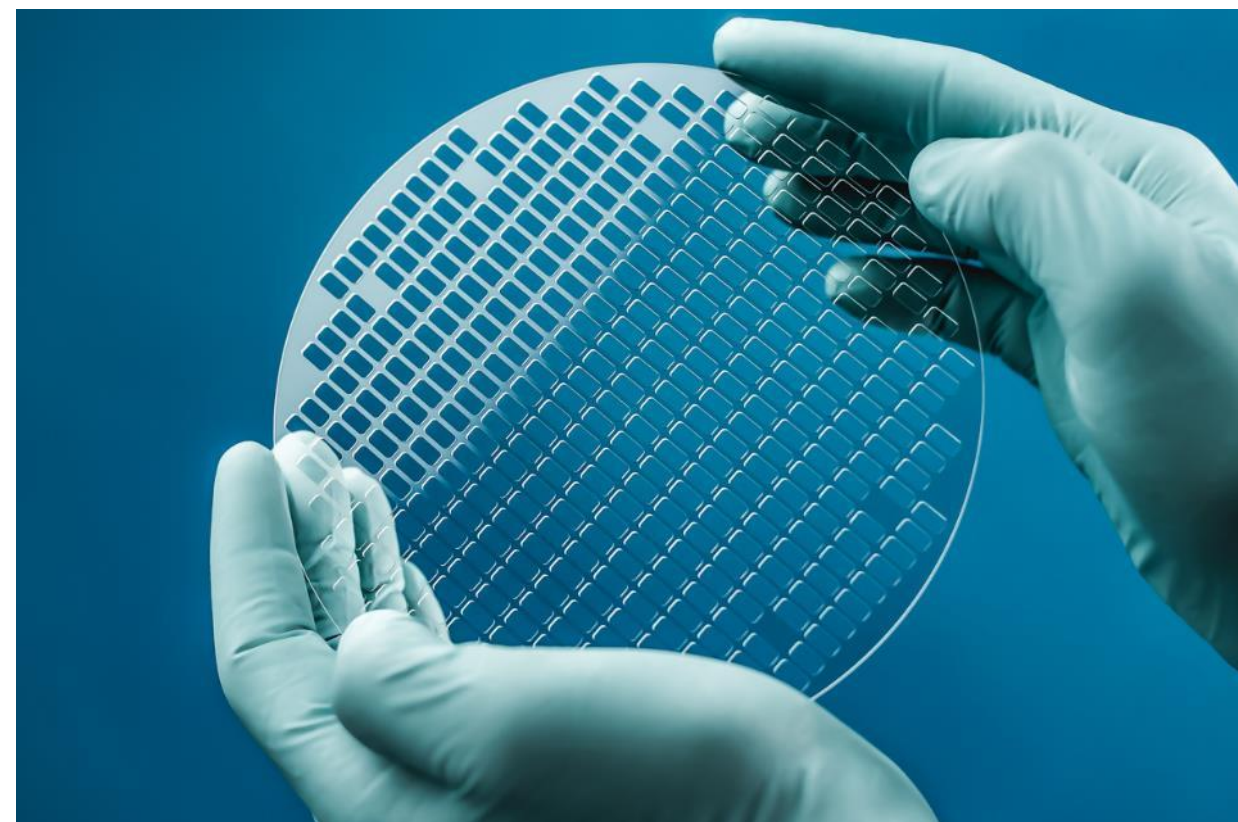
Glass carrier wafers > 8" diameter, 500 μm thickness fused silica wafer



Microfluidic chips & devices



Through glass via (TGV) wafers



Packaging glass products



Switch ceramics to glass for probe cards to reach 80% less defects and 20x faster processing

Precision in microfluidics



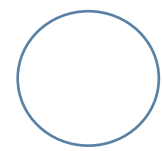
Straight or irregular cuts



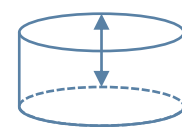
Feature sizes from 10 μm



Substrate thickness from 100 μm to 10 mm



Low chipping <10 μm , typ. none

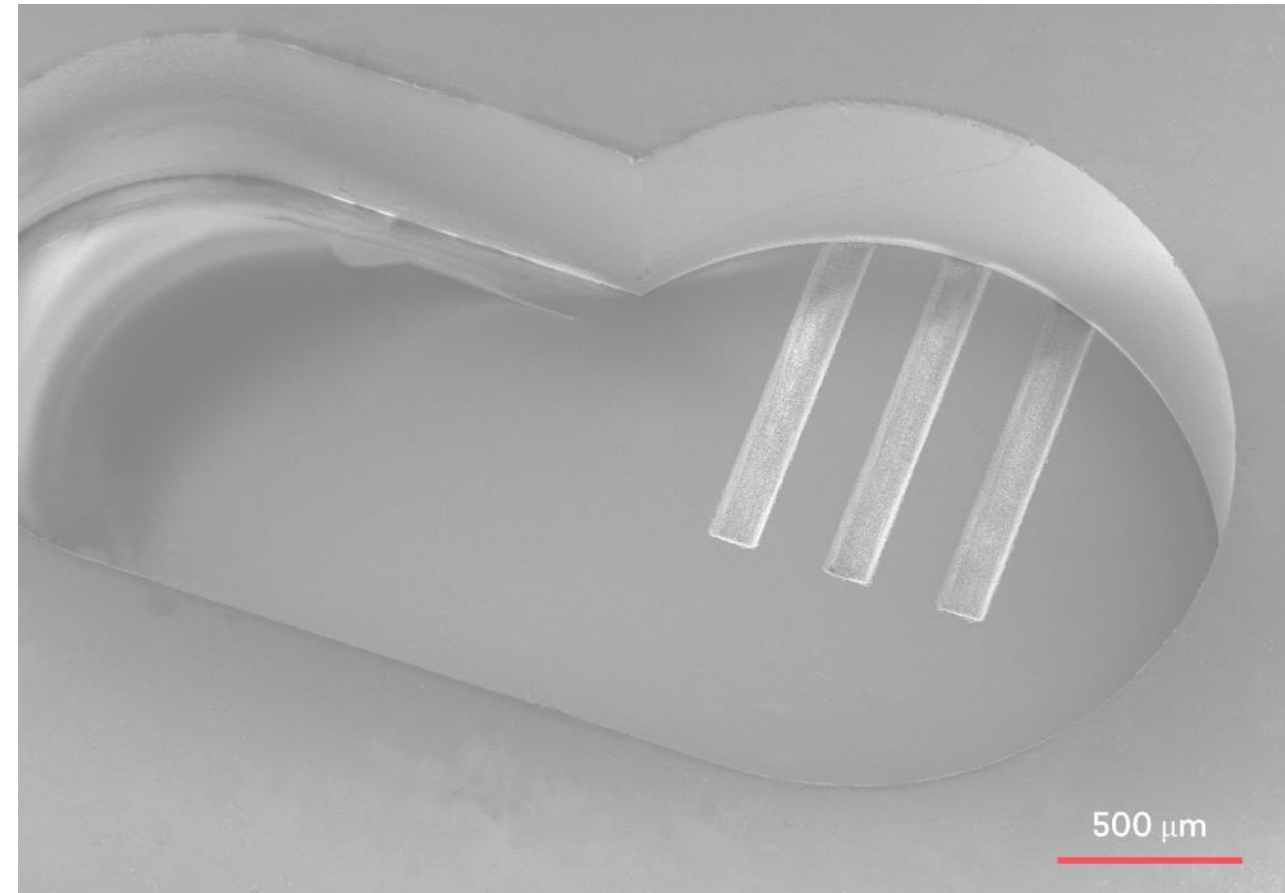


Surface roughness Ra <1 μm or less after polishing

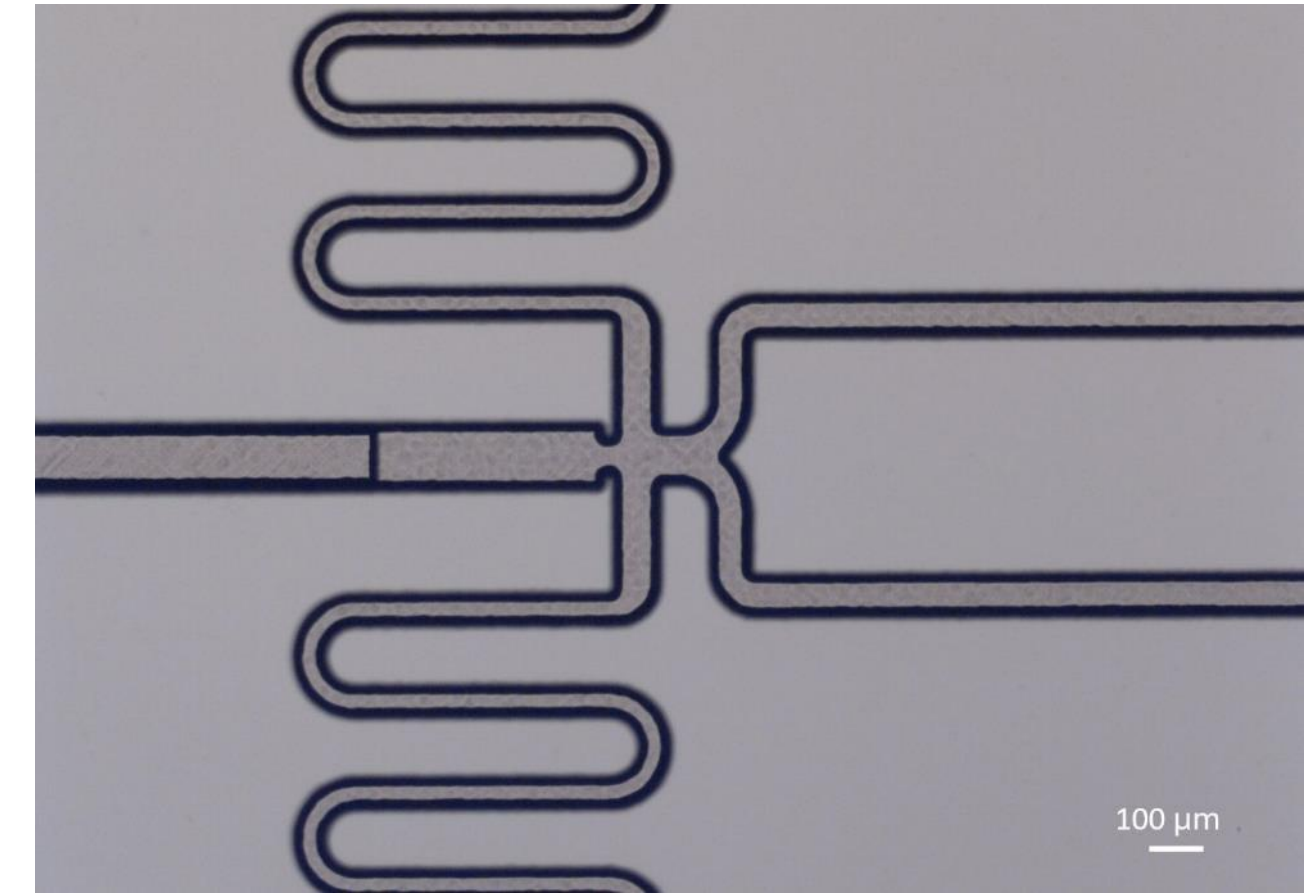


Wide range of channel width and depth

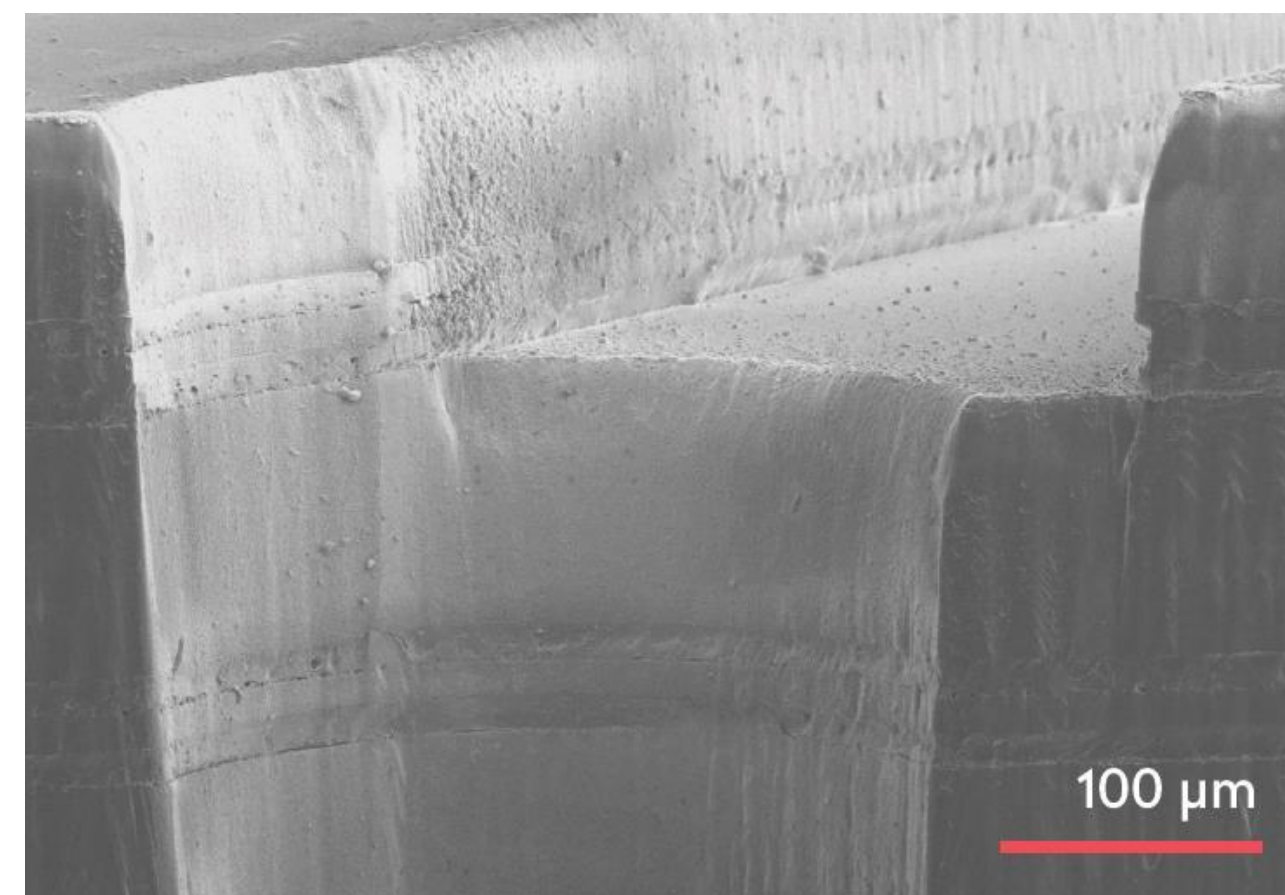
with aspect ratio up to 1:100



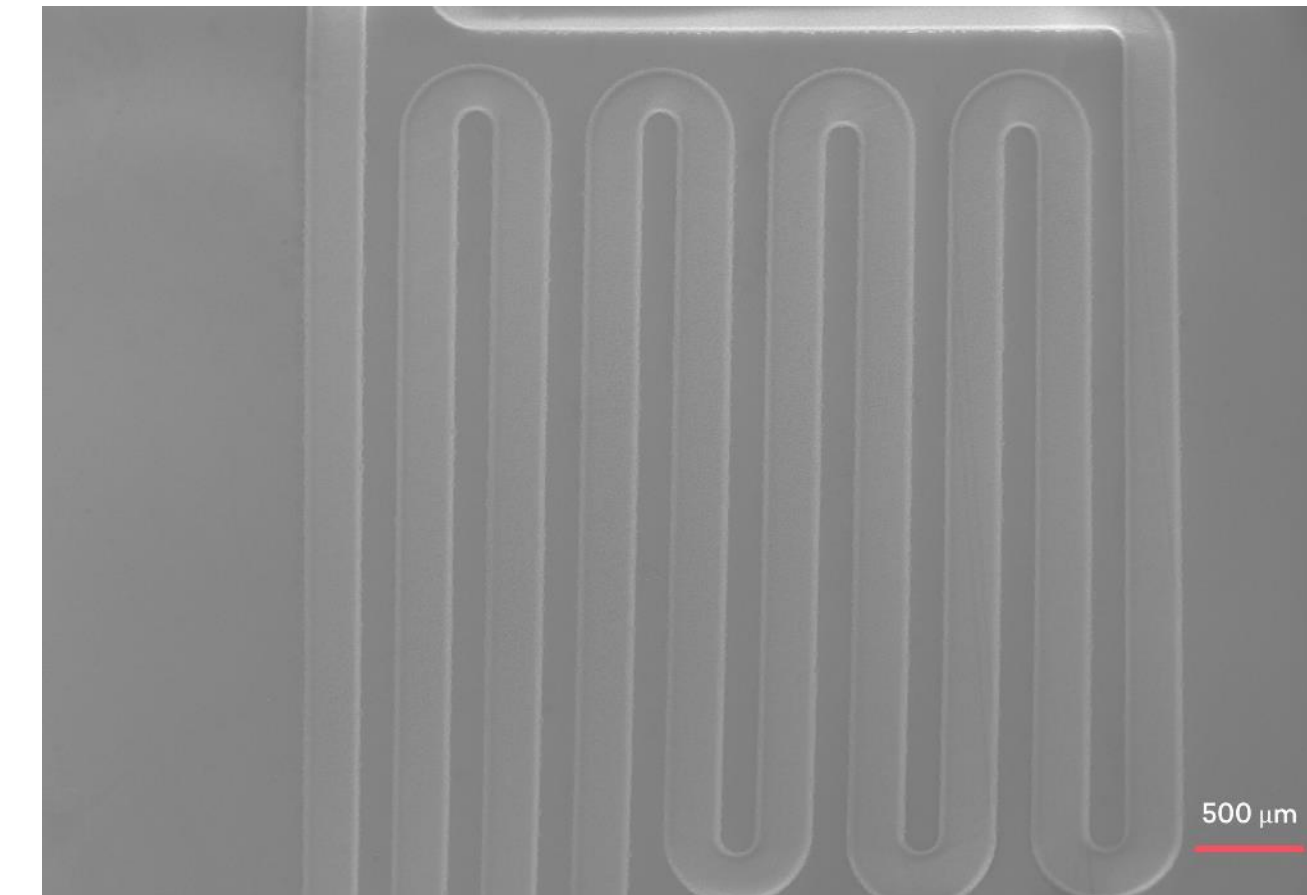
Microfluidics channels drilling with SLE



Microfluidics channels formation in glass

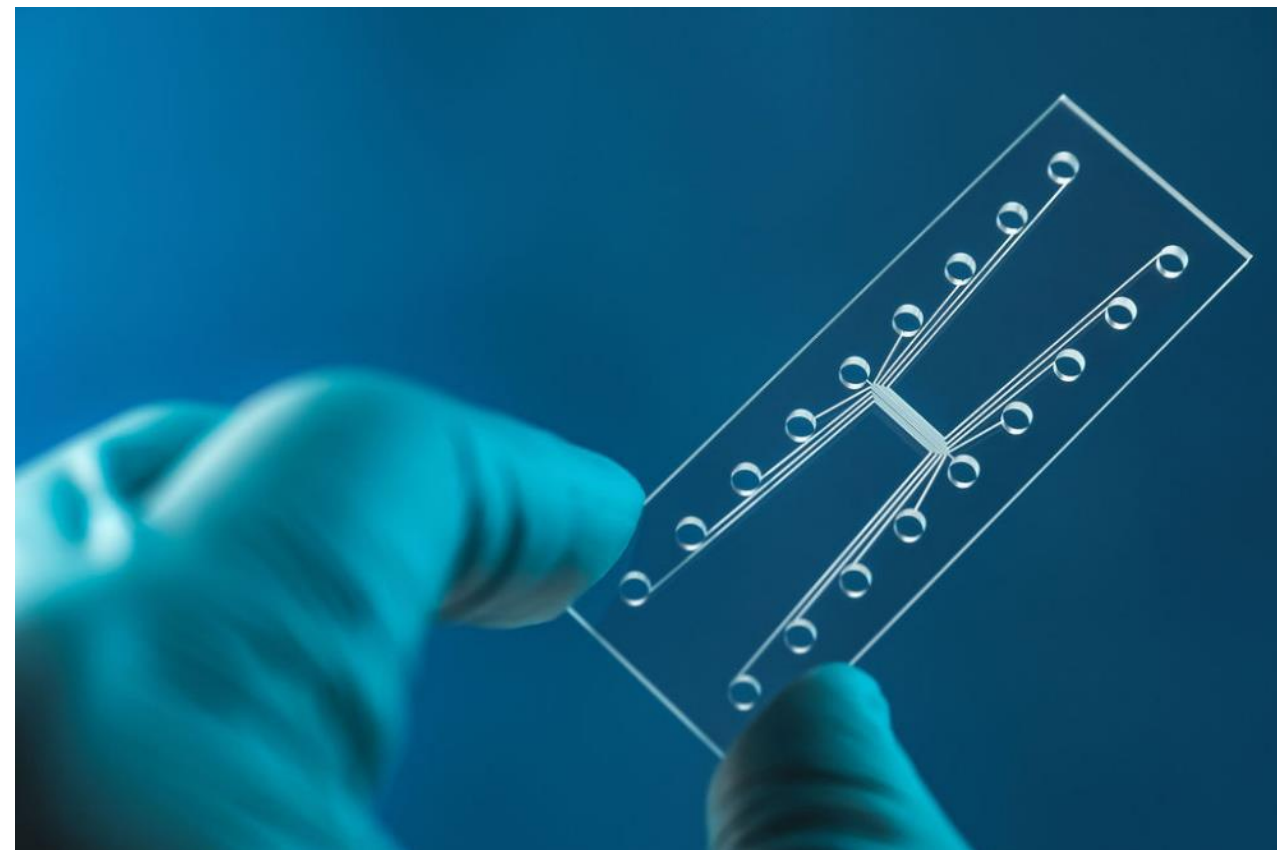
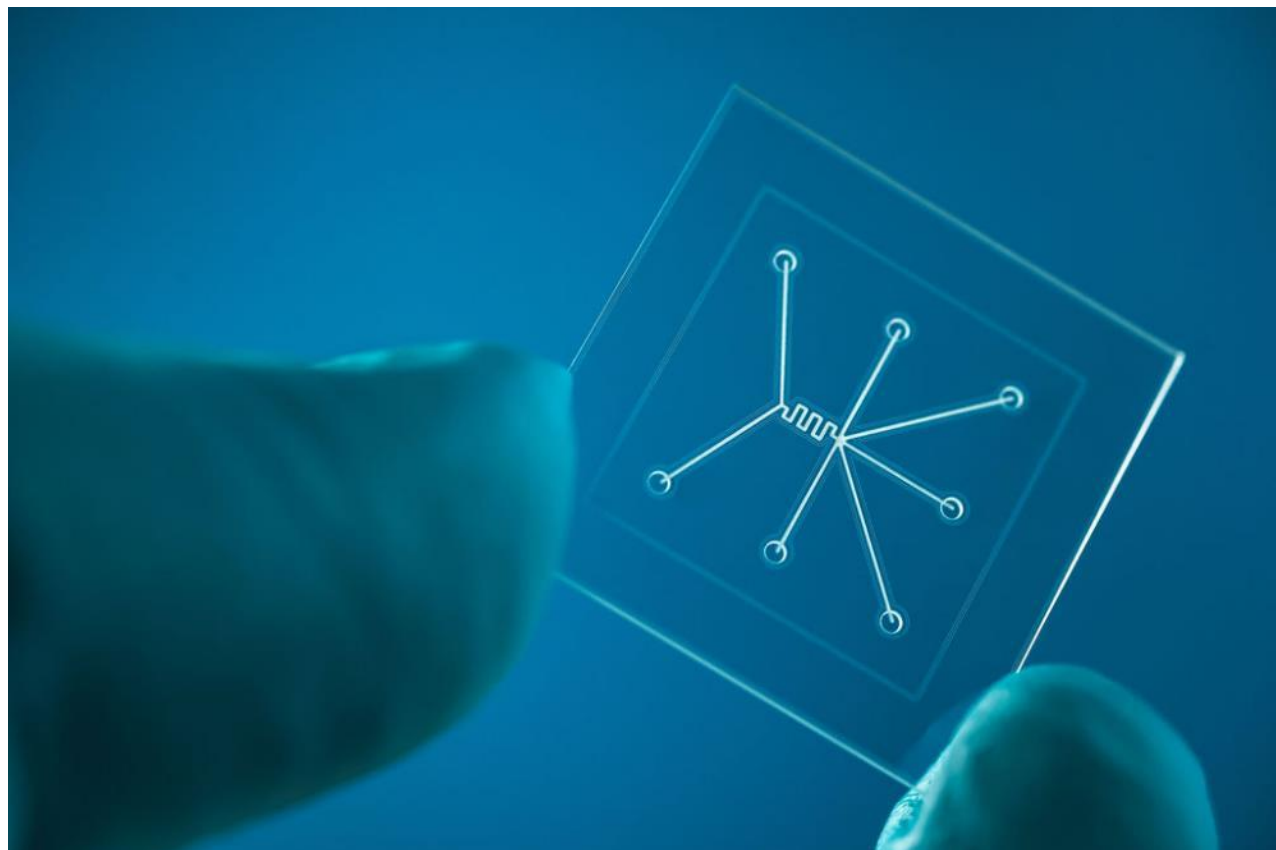
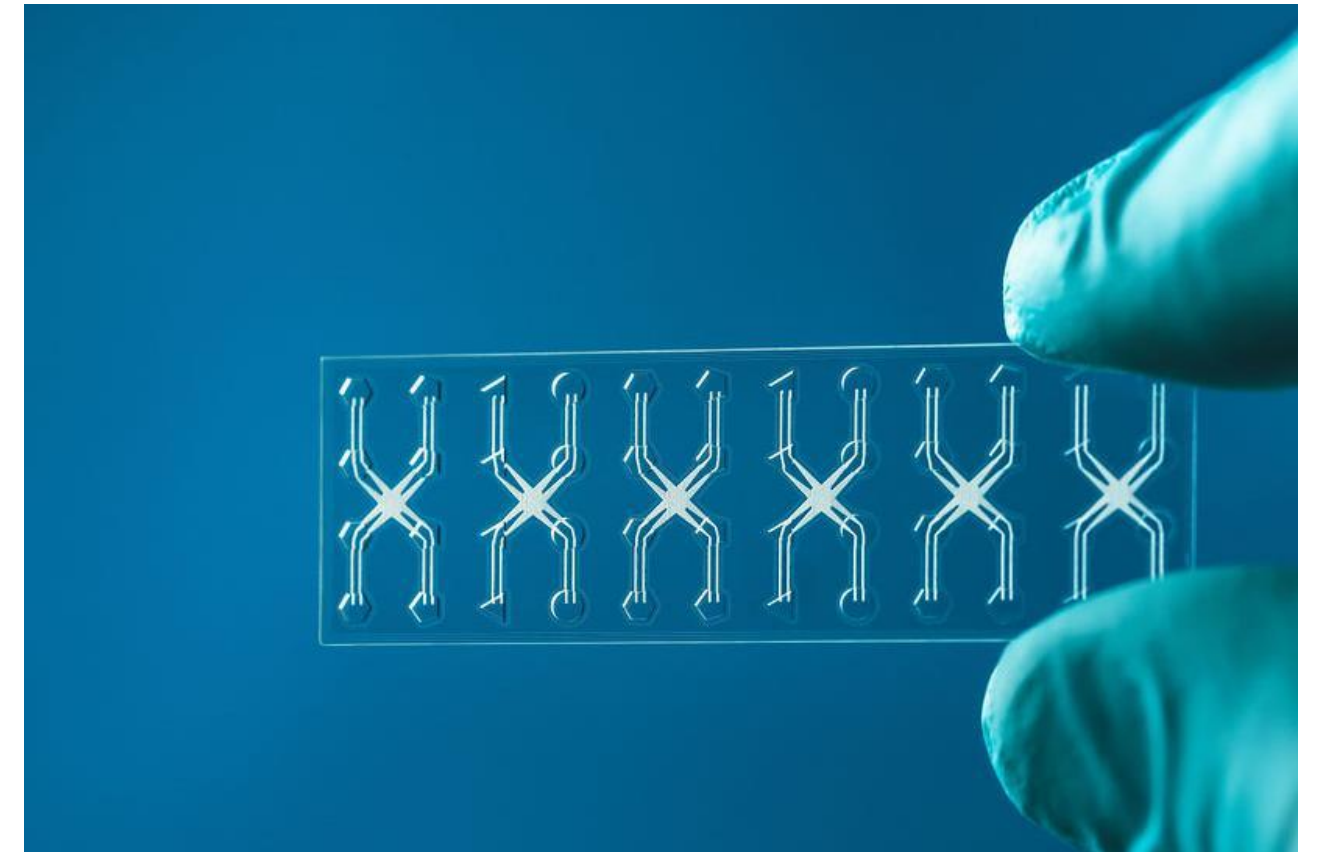
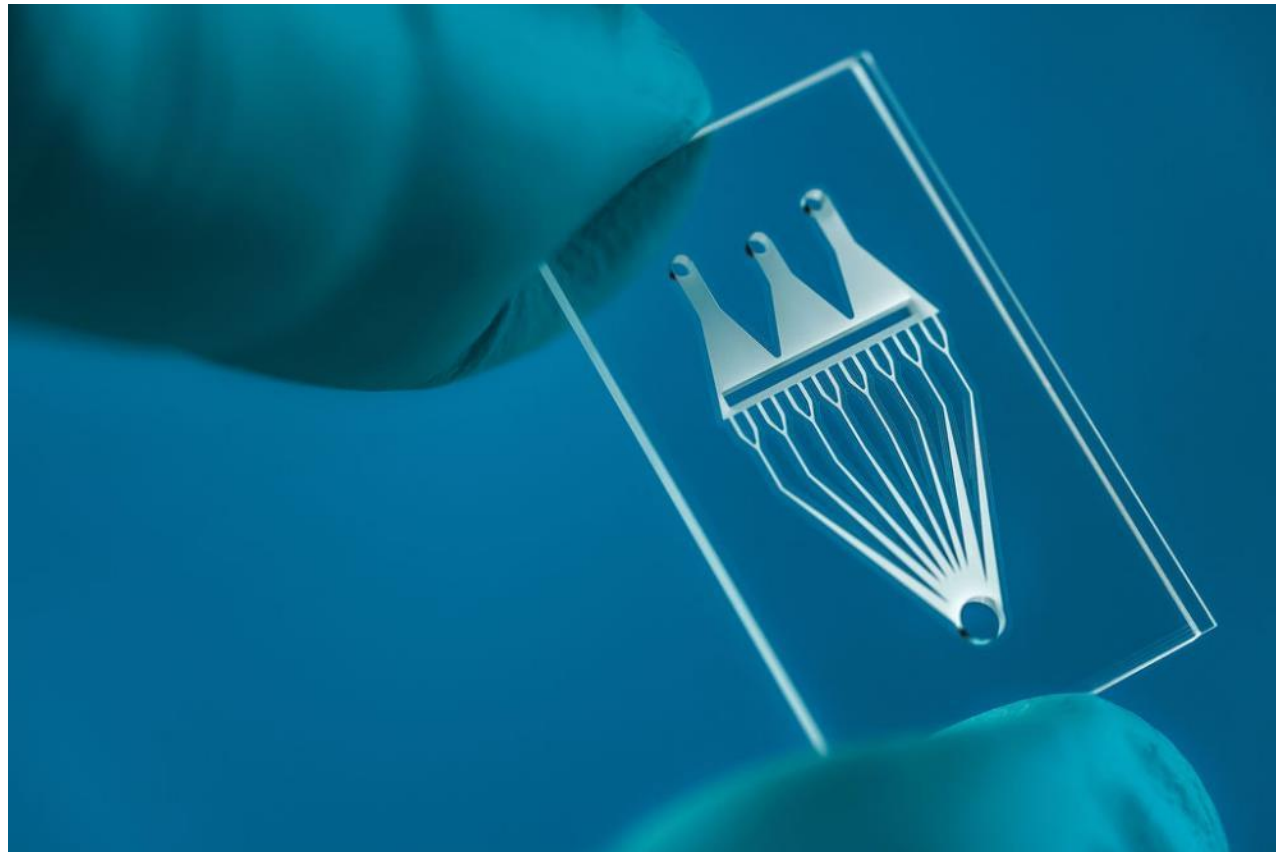


Microfluidics chips channel drilling

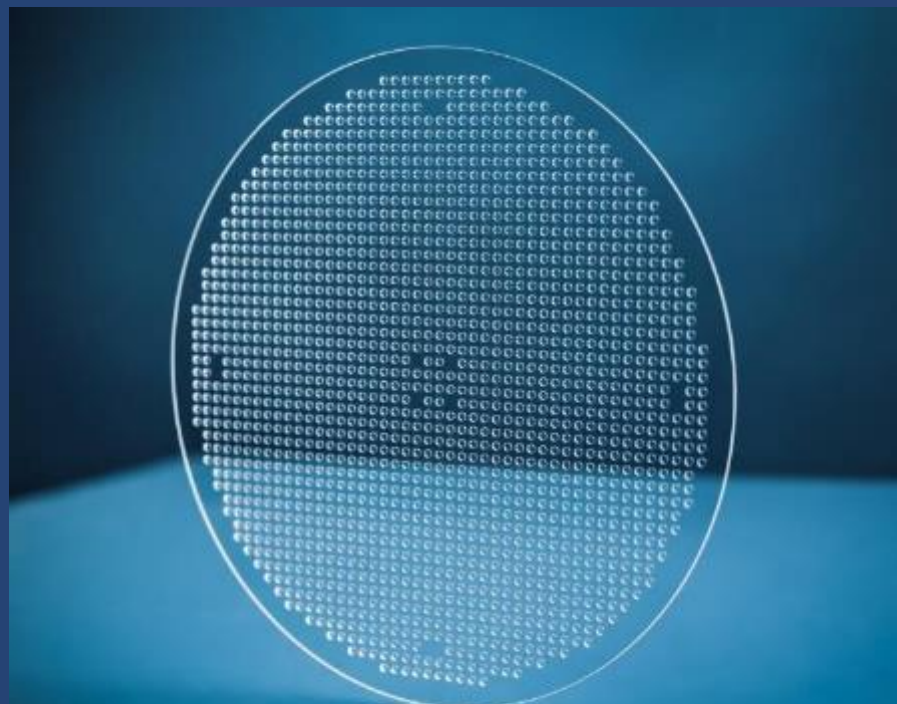


Microfluidics channels formation in glass

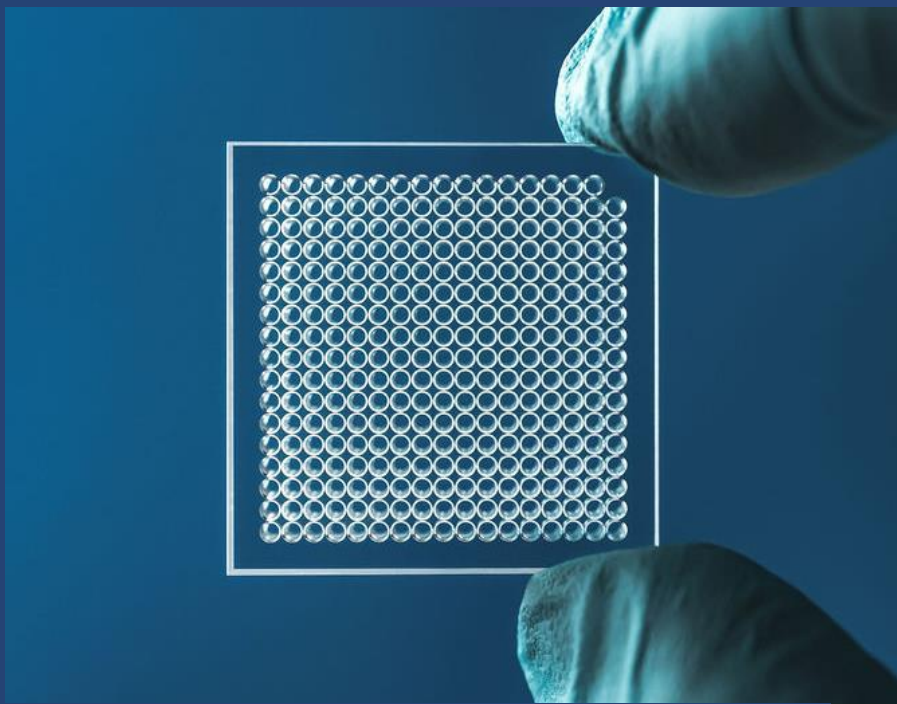
Microfluidics: Custom solutions



Overview



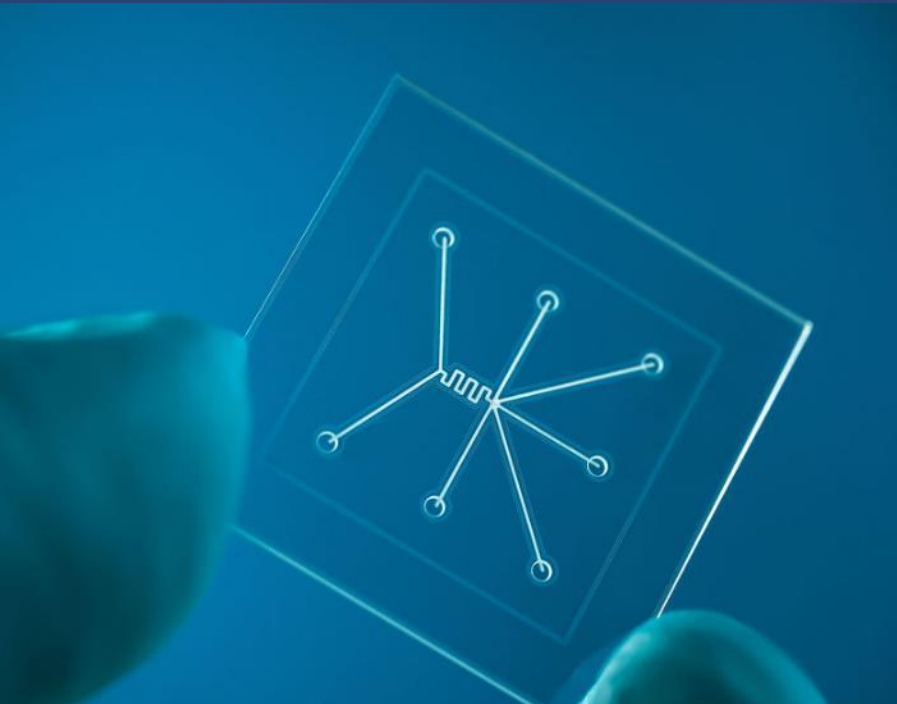
GLASS SPACERS



MICRO DRILLED GLASS



GLASS GUIDE PLATES FOR PROBE CARDS



MICROFLUIDIC CHIPS



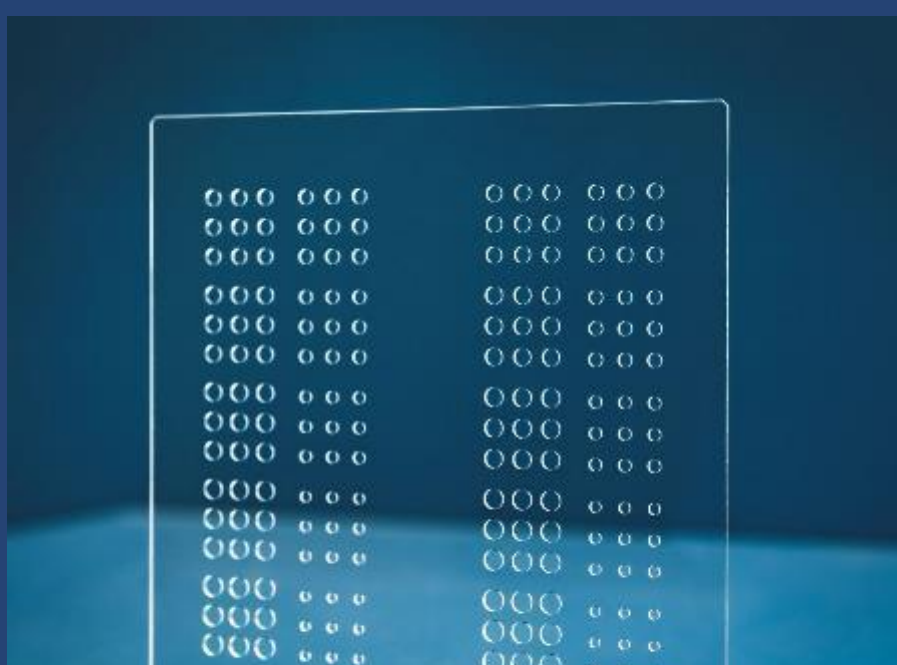
PACKAGING GLASS PRODUCTS



GLASS CARRIER WAFERS



GLASS CUTTING



MICROWELL PLATES



We'll deliver a solution
for your μ task!

Thank you &
let's talk!

Ernestas Nacius
ernestas.nacius@wophotonics.com

Workshop of Photonics | Altechna R&D, UAB
Mokslininku St. 6A, Vilnius
LT-08412 Lithuania

www.wophotonics.com

